Semiconductor Photocatalysis
Electronic Hole Trapping in TiO2

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Semiconductor Photocatalysis: Electronic Hole Trapping in TiO$_2$

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Photocatalysis (the acceleration of a photoreaction in the presence of a catalyst) is presently used in large variety of applications and is one of the possible strategies for future sustainable fuel production from solar energy. A general picture of a photocatalytic process is well known: photogeneration of electron-hole pairs, excess carrier transport to distinct reactive sites and finally carrier utilization in a chemical reaction. For most photocatalyst a detailed understanding of these steps, however, is lacking yet it is crucial to elucidate photocatalyst limitations. Of particular importance is gaining insight into the nature of photogenerated carriers as they play a central role in all the basics steps of a photocatalytic process.

The main objective of this thesis is to elucidate the experimentally observed localized nature of photogenerated electron holes in titanium dioxide—the most studied, yet poorly understood photocatalyst.

By means of the density functional theory (DFT) and its simple extension, the linear expansion $\Delta$ self-consistent field DFT, it is shown that in TiO$_2$ the photogenerated holes self-trap forming $O^-$ small polarons. Self-trapping strength is significantly modified in surface layers due to the variation of surface electrostatic potential. This finding explains differences in photooxidative properties among rutile and anatase TiO$_2$ facades. Optical absorption spectra and hole hopping mobilities of the $O^-$ centers in TiO$_2$ have been calculated. Since time resolved optical spectroscopies are common techniques to study hole dynamics in TiO$_2$ these results should aid analysis of photocatalytic processes on TiO$_2$.

Apart from photocatalysis this thesis also deals with the problem of the local-
ization/delocalization error in approximate DFT functionals—the effect of the incorrect, nonlinear description of fractional electron systems by approximate exchange-correlation functionals. It is shown that by removing the total energy nonlinearity a more consistent description of states with different degrees of localization can be achieved.
Resumé

Fotokatalyse (accelerationen af en fotokemisk reaktion ved tilstedeværelsen af en katalysator) er nu om dage brugt i mange forskellige anvendelser og er en af de mulige strategier for fremtidig vedvarende produktion af brændstof fra solenergi. Det generelle billede af en fotokatalytisk proces er velkendt: Dannelse af elektron-hul par ved fotoeksitation, transport af overskydende ladningsbærere til bestemte reaktive sites og til slut udnyttelsen af ladningsbæreren i en kemisk reaktion. En detaljeret forståelse af disse skridt er dog, for de fleste fotokatalysatorer, mangelfuld, det er dog en vigtig ting at få undersøgt for at forstå begrænsningerne for fotokatalysatorer. Det er særligt vigtigt at få indsigt i de foto-genererede ladningsbæreres natur, da de spiller en central rolle i alle de basale trin af en fotokatalytisk proces.

Hovedformålet med denne afhandling er at belyse de foto-genererede elektron-hul pars eksperimentelt observerede lokaliserede natur i titandioxid—den mest undersøgte, men alligevel lidt forståede fotokatalysator.

This thesis was prepared at the Center for Atomic-scale Materials Design, the Technical University of Denmark in partial fulfillment of the requirements for acquiring the Ph.D. degree.

The main focus is on the effects of photogenerated holes trapping on photocatalytic properties of titanium dioxide. The results are based on density functional theory (DFT) calculations.

It is a pleasure to thank those who made this thesis possible. I wish to express my gratitude to my supervisor, Prof. Jan Rossmeisl for the continuous support of my Ph.D. study and research, for his patience and enthusiasm. I am deeply grateful to my supervisor, Prof. Karsten Wedel Jacobsen for his immense knowledge and great efforts to explain things clearly and simply.

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Last but not least, I would like to thank my entire family for their support throughout the years.

Kongens Lyngby, December 2011
Pawel Zawadzki
Papers included in the thesis


[III] Zawadzki P., Rossmeisl J., Jacobsen K. W.; Polaronic defect states from (semi)local DFT. Application of $\Delta$-SCF DFT to optical absorption of the $V^-$ center in MgO. (manuscript)

[IV] Zawadzki P., Jacobsen K. W., Dahl S., Rossmeisl J.; Explaining oxidative trends of TiO$_2$—Hole trapping at anatase and rutile surfaces. (manuscript)

[V] Zawadzki P.; Transient absorption spectra of anatase TiO$_2$. (manuscript)
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Titanium dioxide (TiO$_2$) is an abundant, chemically inert (in dark) and harmless material. These excellent technological properties translate into a widespread use of this material. In large quantities, TiO$_2$ is used as a white pigment for paints, plastics, paper, fibres, etc. Its whitening properties, in fact, have been known since ancient times.

TiO$_2$, while chemically inert material in dark, in UV light becomes a powerful photocatalyst. The photocatalytic potential of TiO$_2$ has already revealed itself in flaking and bleaching of paints [1]. Research on TiO$_2$ photocatalysis accelerated after Fujishima and Honda published paper on photolytic water decomposition [2]. This discovery in the time of the oil crisis of 1970s triggered hopes for hydrogen fuel based economy. The conversion of solar energy to chemical in a form of hydrogen fuel could provide sustainable solution for rising energy needs. It has been, however, quickly recognised that TiO$_2$ efficiency for hydrogen production is far too low for having a chance to be competitive to fossil fuels—TiO$_2$ large band gap allows to harvest only 3% of the solar spectrum [3]. Nevertheless, TiO$_2$ remains one of the few materials that are able to split water without a use of sacrificial agents.

Photocatalytic properties of TiO$_2$ have much more to offer than the catalysis of the photochemical water splitting reaction. Photogenerated holes in TiO$_2$ are strong oxidising agents for organic compounds [4–6]. Applications for water
and air purification systems, bacteria killing coatings or anti-fogging mirrors, to
name a few, have already entered the market and are enjoying growing demand
(see Fig. 1.1 for illustration).

A basic picture of the semiconductor photocatalysis comprises: photogeneration
of electron-hole pairs, they transport to surface reactive sites where they take
part in chemical transformations [7–11] (see Fig. 1.2). A detailed, atomic-scale
insight into these steps is often lacking, yet it is necessary to elucidate photo-
catalyst limitations and opportunities. The first step to gain such an insight is
to understand the nature of photogenerated carriers as they play a central role
in the basic steps of a photocatalytic process.

The electron paramagnetic resonance of UV irradiated TiO$_2$ samples detects
localized hole and electron centers on oxygen and titanium atoms, respectively
[12–22]. Transient absorption spectroscopy further reveals that the electrons co-
exist in free and localized states whereas holes are predominately trapped [23–
29]. The exact atomic structure, energetics and distribution of trapping sites is,
however, unclear. Particularly important is the elucidation of hole trapping as
holes are minority carriers (TiO$_2$ is an $n$-type semiconductor). Trapping of pho-
togenerated holes might significantly influence their distribution and transport,
and, thus photocatalytic processes.

Despite large amount of experimental data, there have been only few compu-
tational studies of charge trapping in TiO$_2$, see for instance Ref. [30–35]. The
reason for this is that the most common computational technique—the semi-
Figure 1.2: Schematic illustration a photocatalytic process. Photogenerated electron-hole pairs in a semiconductor particle separate and transfer to surface reactive sites where they take part in chemical transformations.

Local density functional theory—often fails to provide even a qualitative picture of charge localization in crystals [36–40].

The aim of this thesis is to provide insight into the atomic and the electronic structure as well as the spacial distribution of hole trapping centers in TiO$_2$.

In order to achieve this goal in chapter 2 I first provide a basic introduction to the density functional theory (DFT)—the computational method used in this thesis. Then, chapter 3 discusses charge trapping in crystals. Here, the focus is on small polarons (charge–polarisation field quasiparticles with size comparable to a lattice spacing), and on the physical origins of trapping. This chapter discusses formation of hole small polarons in TiO$_2$ bulk and in surface layers. In the next chapter, chapter 4, I discuss the application of DFT for description of charge trapping in crystals. The method, due to the total energy nonlinearity problem, often fails to provide even a qualitative picture of charge localization/delocalization processes. This chapter provides a simple correction that allows, in some cases, to overcome this issue. Having introduced the tools and concepts, I apply DFT to small polaron optical transitions in chapter 5 and to small polaron mobility in chapter 6. Finally, chapter 7 analyzes the effects of charge trapping on TiO$_2$ photocatalytic properties.
This thesis also discusses the $V^-$ center in MgO (singly charge Mg vacancy) (chapters 3, 4 and 5). This system served as a test case for the application of DFT to charge localization/delocalization processes.
Chapter 2

Density Functional Theory

The density functional theory (DFT) is the most common computational technique to study materials properties at atomic scale. Starting from the Born-Oppenheimer approximation the method replaces the wave function based description of an atomic system with a computationally more efficient formulation based on the electron density.

This Chapter discusses the basics of DFT. I start by providing founding theorems by Hohenberg and Kohn (HK) and discuss their applicability to fractional electron systems and excited states. The Kohn Sham equations—the most common realization of DFT—is described in Section three. The last section discusses the linear expansion ∆ self-consistent field DFT—a simple extension of the conventional DFT.

2.1 Foundations

The idea that the energy of the electron system can be expressed as a functional of its density reaches 1930s when independent works of Llewellyn Hilleth Thomas [41] (1926) and Enrico Fermi [42] (1927) showed that the kinetic energy of the electron gas in a metal is a functional of the electron density.
The modern theory is based on two theorems by Hohenberg and Kohn [43].

**Theorem 1 (Hohenberg and Kohn)** The ground-state electronic density \( \rho_0(\vec{r}) \) and the ground-state wave-function \( \Psi_0 \) can be used alternatively as full descriptions of the ground state of the system.

This theorem holds for an arbitrary external potential in the absence of magnetic field. The density therefore uniquely (up to a trivial constant) defines the external potential, and thus all the properties of the system. This property of the density is termed \( v \)-representability.

If an external potential is due to atomic nuclei, the theorem can be justified in a particularly simple manner: Given the electron density \( \rho(\vec{r}) \) one can identify positions of the nuclei by examining the density for cusps. The atomic number \( Z_a \) of the nucleus \( a \) at position \( R_a \) then can be determined using the cusp condition [44]:

\[
Z_a = \frac{1}{2\rho(\vec{r})} \frac{\partial \rho(\vec{r})}{\partial r} \bigg|_{r=R_a},
\]

which ensures that the wave-function (and the density) does not explode to the infinity at \( r = R_a \). The total number of electrons is simply the integral over the density. Having the positions of the nuclei, their atomic numbers and the total number of electrons, the Hamiltonian can be constructed and, in principle, solved for the ground state wave function.

The second theorem provides a practical tool for calculating the ground state energy—a variational principle.

**Theorem 2 (Hohenberg and Kohn)** For a given number of electrons and external potential \( v \), there exists a functional of \( \rho \), \( E_v[\rho] \), for which the following variational principle is satisfied \( E_v[\rho] \geq E_v[\rho_0] = E_0 \), where \( \rho_0 \) stands for the ground state electronic density and \( E_0 \) is the ground state energy.

Levy proved that such functional can be constructed from densities that are \( N \)-representable—nonnegative, continuous, and integrable to \( N \) electrons—a set that is more easily defined than \( v \)-representable densities [45]. The proof is realized via two step constraint minimization:

- over all \( N \)-electron, normalized wave-functions \( \Psi_N \) that give a certain density \( \rho \),
- over all densities \( \rho \) that integrate to \( N \) electrons.
2.1 Foundations

\[ E_0 = \min_{\rho \to N} \min_{\Psi_N \to \rho} \langle \Psi_N | H | \Psi_N \rangle, \quad (2.2) \]

where \( H \) consist of the electron kinetic energy \( T \), the electron repulsion \( U \) and the electron interaction with the external potential \( v(\vec{r}) \). Since the latter is simply

\[ V[\rho] = \int v(\vec{r})\rho(\vec{r})d^3\vec{r}, \quad (2.3) \]

the variational principle for the ground state energy can be realized as minimization over the set of \( N \)-representable densities.

\[ E_0 = \min_{\rho \to N} \{ V[\rho] + F_{HK}[\rho] \}, \quad (2.4) \]

where \( F_{HK}[\rho] \) is universal, \( v \)-independent functional of the electron density. The exact form of \( F_{HK}[\rho] \) is unknown and for practical implementations approximate constructions are used. The most common is the Kohn-Sham model of a fictitious noninteracting electron system which is described in Section 2.2.

2.1.1 Noninteger electron numbers

Eq. 2.4 constrains the minimisation to densities \( \rho \) that integrate to \( N \) electrons

\[ \int \rho(\vec{r})d^3r = N. \quad (2.5) \]

Such minimization realized via introduction of a Lagrange multiplier \( \mu \)

\[ \frac{\delta [E_v[\rho] - \mu \int \rho(\vec{r})d^3r]}{\delta \rho} = 0, \quad (2.6) \]

allows the electron density integral to assume a fractional value. For a closed system fractional electron numbers does not have any physical significance. They may arise, however, in an open system as a time average over an ensemble of pure states. System with \( N + \omega \) electrons and \( \omega \in [0, 1] \) is thus a statistical mixture of an \( N \) electron system with the probability \( 1 - \omega \) and an \( N + 1 \) electron system with the probability \( \omega \) [46].

The variational principle can be realized as a two step constrained search: minimization of the energy over ensembles that yield the given density and minimization over all densities that integrate to the given electron number \( N + \omega \)

\[ E_0 = \min_{\rho \to N+\omega} \min_{\Psi_N, \Psi_{N+1} \to \rho} \{(1 - \omega)\langle \Psi_N | H | \Psi_N \rangle + \omega\langle \Psi_{N+1} | H | \Psi_{N+1} \rangle \}. \quad (2.7) \]
For such statistical mixture subjected to an external potential $v$ the minimum of the energy is attained for:

$$\rho_{N+\omega} = (1 - \omega)\rho_N + \omega \rho_{N+1},$$  \hspace{1cm} (2.8)

and

$$E_{N+\omega} = (1 - \omega)E_N + \omega E_{N+1}. \hspace{1cm} (2.9)$$

The energy is therefore linear in segments between integer electron numbers.

### 2.1.2 Excited states

The excited state density does not uniquely define the external potential and therefore Hohenberg-Kohn theorems are invalid for excited states [47]. The variational principle for $i$th excited state requires knowledge of $i-1$ lowest states of the Hamiltonian so that minimization can be performed over subset of Hilbert space orthogonal to $i-1$ levels.

To realize the variational principle for the excited density, Levy’s two step constraint search can be employed. The first minimization is performed over all wave-functions that are orthogonal to the lowest $i-1$ states of the Hamiltonian and give excited state density $\rho$. The second minimization is a search over all densities that integrate to the total number of electrons $N$.

$$E_i = \min_{\rho \rightarrow N} \min_{\Psi_N \rightarrow \rho} \langle \Psi_N | H | \Psi_N \rangle. \hspace{1cm} (2.10)$$

Similarly to Eq. 2.4 the excited state energy functional takes the form

$$E_i = \min_{\rho \rightarrow N} \left\{ \int v(\vec{r})\rho(\vec{r})d^3\vec{r} + F_i[\rho, \rho_0] \right\}. \hspace{1cm} (2.11)$$

Now, since the knowledge of the $i-1$ lowest excited states is required, the energy is bifunctional of the ground state density (or potential) and the excited state density.

For Coulombic external potentials the cusp condition (or its modified version) also holds for excited state densities [48], therefore the Hamiltonian can be constructed, in a way described in Sec. 2.1, from the exact excited state density. Finding the exact excited state density however, is highly nontrivial as requires knowledge of $F_i[\rho, \rho_0]$. 
2.2 Kohn-Sham equations

The exact form of the universal functional $F_{HK}[\rho]$ is unknown and for practical implementations approximate constructions are used. Kohn and Sham proposed a scheme that replaces the problem of interacting many electron system with a noninteracting electron gas in a fictitious effective potential $v_{eff}$ so that the exact ground state density of the system is reproduced. Electrons are hence described by a single particle Schrödinger equations

$$\left(-\frac{1}{2}\Delta + v_{eff}\right)|\psi_n\rangle = \varepsilon_n|\psi_n\rangle. \quad (2.12)$$

The wave function of noninteracting many electron system is a Slater determinant constructed from the KS orbitals $|\psi_n\rangle$ and the total electron density of the $N$ electron system is

$$\rho(r) = \sum_n |\psi_n|^2. \quad (2.13)$$

Kohn-Sham’s construction of the potential $v_{eff}$ is based on energy expression

$$E[\rho] = T_0 + V[\rho(\vec{r})] + J[\rho(\vec{r})] + E_{xc}[\rho(\vec{r})], \quad (2.14)$$

where $T_0$ is the kinetic energy of the Kohn-Sham system

$$T_0 = -\frac{1}{2} \sum_n \langle \psi_n | \Delta | \psi_n \rangle, \quad (2.15)$$

$V[\rho(\vec{r})]$ is the interaction with an external potential $v(\vec{r})$

$$V[\rho(\vec{r})] = \int v(\vec{r}) \rho(\vec{r}) d^3\vec{r}, \quad (2.16)$$

$J[\rho(\vec{r})]$ is the electron density self-interaction

$$J[\rho(\vec{r})] = \frac{1}{2} \int \frac{\rho(\vec{r}) \rho(\vec{r}')}{|\vec{r} - \vec{r}'|} d^3\vec{r}', \quad (2.17)$$

and $E_{xc}$ accounts for the exchange and correlation effects as well as for the difference in kinetic energy between the real (interacting) electron and the fictitious noninteracting Kohn-Sham systems.

By minimizing the energy functional with respect to change in Kohn-Sham orbitals, the potential $v_{eff}$ is found to be

$$v_{eff} = v_c + v_{xc} + v, \quad (2.18)$$

atomic units apply $m_e = \hbar = a_0 = e = 1$
where $v_{c}$ is the Coulomb potential due to the electron density

$$v_{c}(\vec{r}) = \int \frac{\rho(\vec{r}')}{|\vec{r} - \vec{r}'|} d^3r',$$  \hspace{1cm} (2.19)

$v_{xc}$ is the exchange correlation potential

$$v_{xc}(\vec{r}) = \frac{\delta E_{xc}[\rho(\vec{r})]}{\delta \rho(\vec{r})},$$  \hspace{1cm} (2.20)

and $v$ is the external potential.

### 2.2.1 Exchange-correlation energy

The exchange-correlation energy $E_{xc}$ is the only unknown component of the total energy expression for the Kohn-Sham system Eq. 2.14. A physical insight into this term can be gained through the adiabatic-connection approach. The method introduces scaled electron-electron interaction $\lambda U(\vec{r}, \vec{r}')$ where $\lambda \in [0, 1]$ and an external potential $v_{\text{ext}}^\lambda$ chosen so that for all $\lambda$ the electron density equals to the true density. The external potential for $\lambda = 0$ is the effective Kohn-Sham potential whereas for $\lambda = 1$ is the true external potential. The method leads to the following expression for exchange correlation energy:

$$E_{xc}[\rho(\vec{r})] = \int_{0}^{1} \langle \Psi_\lambda | U | \Psi_\lambda \rangle d\lambda - J[\rho(\vec{r})],$$  \hspace{1cm} (2.21)

which can be cast into form

$$E_{xc}[\rho(\vec{r})] = \frac{1}{2} \int \rho(\vec{r}) \frac{\rho_{xc}(\vec{r}, \vec{r}')}{|\vec{r} - \vec{r}'|} d\vec{r'} d\vec{r},$$  \hspace{1cm} (2.22)

$$= \int \rho(\vec{r}) \epsilon_{xc}[\rho(\vec{r})] d\vec{r},$$  \hspace{1cm} (2.23)

where $\rho_{xc}(\vec{r}, \vec{r}')$ is the exchange correlation hole averaged over $\lambda$ and $\epsilon_{xc}[\rho(\vec{r})]$ is the exchange-correlation energy per electron. Exchange correlation hole defines a region of reduced probability of encountering a second electron around a given reference electron

$$\rho_{xc}(\vec{r}, \vec{r}') = \frac{\rho(\vec{r}, \vec{r}')}{\rho(\vec{r})} - \rho(\vec{r}),$$  \hspace{1cm} (2.24)

where $\rho(\vec{r}, \vec{r}')$ is the two electron density matrix. The hole is created by Pauli exclusion principle (exchange hole) and Coulomb repulsion (correlation hole) effects and for integer electron number satisfies the sum rule

$$\int \rho_{xc}(\vec{r}, \vec{r}') d\vec{r} = -1.$$  \hspace{1cm} (2.25)
The exchange-correlation energy is therefore the interaction energy between the electron density and the XC hole.

There are numbers of approximations for the exchange correlation energy. The simplest is the local density approximation (LDA) that assumes $\epsilon_{xc}$ to be a local function of electron density of a homogeneous electron gas $\epsilon_{xc}^{homo}(\rho(\vec{r}))$.

An improvement is obtained by inclusion of a density-gradient via enhancement factor $F_{xc}(\rho(\vec{r}), |\nabla \rho(\vec{r})|)$—the generalized gradient approximation (GGA).

### 2.3 Linear expansion \(\Delta\)-SCF

The linear expansion \(\Delta\)-SCF is an approximate technique to calculate excited state energies that uses [49]

- ground state energy functional,
- approximate excited state density.

The excited state density is constructed by adding or subtracting the density of an orbital $|\phi\rangle$ expanded in KS states while conserving the total number of electrons:

$$\rho(r) = \sum_n f_{N\pm 1}(\varepsilon_n) |\psi_n(\vec{r})|^2 \mp |\phi(\vec{r})|^2$$

(2.26)

where $f$ is Fermi-Dirac distribution and

$$|\phi\rangle = \sum_n \langle \psi_n |\phi\rangle |\psi_n\rangle$$

(2.27)

The Kohn-Sham equations are then solved till self-consistently is achieved.

The difficult part in application of \(\Delta\)-SCF is choice of the orbital $|\phi\rangle$ that will lead to excited state density. A physical insight into the nature of the excited state is necessary. Knowledge of the symmetry and the nodal structure of the excited state is helpful.
The role of a semiconductor photocatalyst is to accelerate a photochemical reaction by transferring photon energy to reactants via photogenerated electron hole pairs in a semiconductor. Understanding the nature of the photogenerated carriers is therefore crucial for understanding of photocatalytic processes. Most basically, electrons and holes in crystal can be characterized by their degree of charge localization. In a perfect crystal lattice carriers are delocalized—their wave function is a Bloch state. Interaction with various lattice inhomogeneities, as well as coupling to lattice vibrational degrees of freedom, may lead to carrier localization.

The first section of this chapter outlines the mechanisms that lead to a charge localization and discusses factors that determine the spacial extent of the localized state. In particular, the focus is on small polarons—electron(hole)-polarisation field quasiparticles with the size comparable to lattice spacing. Section two provides examples for small-polarons formed due to a strong electron-lattice coupling as well as due to interaction with a defect potential.
3.1 Charge localization

The possibility of electron self-trapping was first predicted by Landau in 1933 [50]. An electron in a polarizable medium “digs” a potential well for itself.

\[ V = -\frac{e^2}{\varepsilon_{\text{eff}} r}, \quad \frac{1}{\varepsilon_{\text{eff}}} = \frac{1}{\varepsilon_{\infty}} - \frac{1}{\varepsilon_0} \]  

(3.1)

where \( \varepsilon_\infty \) and \( \varepsilon_0 \) are optical and static dielectric constants, respectively. \( \varepsilon_{\text{eff}} \) represents the strength of the dielectric response of the medium (lattice) to a charge perturbation. According to Eq. 3.1 in nonpolar crystals, such as silicon, no polaronic effect is expected \( \varepsilon_\infty = \varepsilon_0 \), therefore, a quasiparticle composed of the electron and the induced polarisation field was termed a polaron. This simplistic picture holds if the polaronic radius

\[ a \sim \frac{\hbar^2 \varepsilon_{\text{eff}}}{e^2 m_{\text{eff}}}, \]  

(3.2)

is larger than the lattice spacing—a large polaron limit. A polaron radius smaller than lattice spacing (a small polaron) can arise in the presence of short range interactions.

3.1.1 Continuum model

The existence of small and large polaron limits were clearly explained by Emin and Holstein [51]. They analyzed the adiabatic picture of the electron–continuum (electron–lattice) interaction using Hamiltonian of the form:

\[ H_e = \hat{T}_e + \int d\vec{r}' Z(\vec{r}, \vec{r}') \Delta(\vec{r}'), \]  

(3.3)

where \( \hat{T}_e \) is the electron kinetic energy operator; \( Z(\vec{r}, \vec{r}') \) is the strength of the interaction between the electron at \( r' \) and the continuum deformation \( \Delta(\vec{r}') \). The total energy then is a sum of the electronic part

\[ E_e = \int d\vec{r} \Psi(\vec{r}) H_e \Psi(\vec{r}) = T_e + V_{\text{int}}, \]  

(3.4)

and the strain energy of the medium, which in a harmonic approximation takes the form

\[ E_s = \frac{1}{2} S \int d\vec{r} \Delta^2(\vec{r}). \]  

(3.5)

The minimum of the total energy is achieved when deformation is

\[ \Delta(\vec{r}) = \frac{1}{S} \int d\vec{r}' \Delta^2(\vec{r}') Z(\vec{r}, \vec{r}'), \]  

(3.6)
3.1 Charge localization

and the strain energy takes the value $E_s = V_{\text{int}}/2$.

Further, Emin and Holstein decomposed the electron–medium interaction into a long and a short range contribution. The long range part arises due to the displacements of positive and negative components of the polar medium. The first nonvanishing term is $Z(\vec{r}, \vec{r}') = E_L|\vec{r} - \vec{r}'|^2$. For the short range part they assumed a delta function $Z(\vec{r}, \vec{r}') = E_S\delta(\vec{r}, \vec{r}')$.

By scaling the original electron wave function $\Psi(\vec{r})$ in three dimensions of spacial coordinate

$$R^{-\frac{3}{2}}\Psi\left(\frac{\vec{r}}{R}\right),$$

the minimum of the total energy can be expressed as a function of the extension of the electron localization $R$

$$E(R) = \frac{T_e}{R^2} - \frac{1}{2}\left(\frac{V_s}{R^3} + \frac{V_{sL}}{R^2} + \frac{V_L}{R}\right),$$

where the constants are defined through:

$$T_e = \frac{\hbar^2}{2m} \int d\vec{r} |\nabla \Psi(\vec{r})|^2,$$

$$V_{s\text{int}} = \frac{E_S^2}{S} \int d\vec{r} |\Psi(\vec{r})|^4,$$

$$V_{sL\text{int}} = \frac{2E_SE_L}{S} \int d\vec{r} \int d\vec{r'} |\Psi(\vec{r})|^2 |\Psi(\vec{r}')|^2 \frac{1}{|\vec{r} - \vec{r}'|^2},$$

$$V_{L\text{int}} = \frac{E_L^2}{S} \int d\vec{r} \int d\vec{r'} \int d\vec{r''} \frac{|\Psi(\vec{r})|^2 |\Psi(\vec{r}')|^2}{|\vec{r} - \vec{r}'|^2 |\vec{r} - \vec{r''}|^2}.$$}

The effects of the relative magnitude of these components on the electron localization are shown in Fig. 3.1.

- Fig. 3.1a—only the long range interaction is present: $V_{s\text{int}} = V_{sL\text{int}} = 0$.
  The energy is given by $E(R) = T_e/R^2 - V_{L\text{int}}/2R$ and has a minimum at $R = 4T_e/V_{L\text{int}}$. This limit corresponds to a large polaron.

- Fig. 3.1b—only the short range interaction is present: $V_{L\text{int}} = V_{sL\text{int}} = 0$.
  The energy is given by $E(R) = T_e/R^2 - V_{s\text{int}}/2R^3$ and has two minima at $R \to 0$ and $R \to \infty$. The former corresponds to a small polaron limit, whereas the latter to an unbound electron state. In a discreet lattice the size of the small polaron is finite as the strain energy and the electron-lattice interaction saturate when $R$ is comparable to lattice spacing. Therefore when the size of the small polaron exceeds the barrier at $R = 3V_{s\text{int}}/4T_e$, it becomes unbound.
Figure 3.1: Effects of the short and the long range interaction on the spacial extend of the electron wave function: a) only long range interaction is present—large polaron is formed; b) only short range interaction is present—small polaron is formed; c) both interactions are present—the small and the large polarons can coexist; d) both interactions are present—the short range interaction is sufficiently strong and the large polaron collapses into the small polaron state. Figure reproduced from Ref. [51].

- Adding the long range to the short range interaction converts the unbound state at \( R \to \infty \) to the bound one (large polaron)—Fig. 3.1c. If the interaction is sufficiently strong the large polaron collapses into the small polaron state—Fig. 3.1d.

### 3.1.2 Lattice model

To correctly account for the finite size of the small polaron a discreet lattice model is necessary. Shinozuka and Toyozawa considered a simple single band lattice Hamiltonian [52]:

\[
H_0 = \sum_k (\varepsilon + t_k)|k\rangle\langle k| + \frac{K}{2}Q_0^2, \tag{3.13}
\]
where $\varepsilon + t_k$ is the band dispersion and

$$|\mathbf{k}\rangle = \frac{1}{\sqrt{N}} \sum_n e^{i\mathbf{k}\mathbf{R}_n} |n\rangle,$$

(3.14)

is the Bloch state formed from lattice orbitals $|n\rangle$.

The charge localization on a single site 0 can be induced by the defect potential $-\Delta$ and/or linear electron-lattice coupling $-DQ_0$:

$$H_1 = -(\Delta + DQ_0) |0\rangle\langle 0|.$$

(3.15)

Solution of

$$H = H_0 + H_1$$

(3.16)

for a simple cubic lattice of $s$-like orbitals leads to two types of the lowest energy states: a free state at the bottom of the band with energy

$$E(Q_0) = \varepsilon - \frac{T}{2} + \frac{K}{2} Q_0^2,$$

(3.17)

and a localized state on the lattice site 0 with energy

$$E(Q_0) = \varepsilon - (DQ_0 + \Delta) - \frac{T^2}{24 (DQ_0 + \Delta)} - \frac{T^4}{1152 (DQ_0 + \Delta)^3} - \cdots + \frac{K}{2} Q_0^2.$$

(3.18)

where $T$ is the band width. The solutions can be characterized by two dimensionless parameters:

- $D/T$ describing the strength of the electron–lattice interaction;
- $\Delta/T$ describing the depth of the potential well due to the defect.

Fig. 3.2 shows the potential energy surfaces for different $D/T$ and $\Delta/T$ values. Both the electron interaction with the lattice deformation and the defect potential can lead to the formation of a small-polaron. These two origins of trapped electron states are often termed [53] as:

- The intrinsic self-trapping—trapping due to interaction with the lattice ($\Delta = 0$);
- The extrinsic self-trapping—trapping due to interaction with the defect ($D = 0$).
Figure 3.2: Adiabatic potential energy surfaces along lattice distortion $Q_0$ associated with lattice site 0. The energy is expressed in units of $T$ (the electron band width) and $K = 0.6T$ (see Eq. 3.13). The electron interaction with the lattice distortion $D$ and/or with the defect potential $\Delta$ can lead to the formation of the localized bound state.

3.2 Examples

3.2.1 $V^-$ center in MgO

Fig. 3.3 shows nonadiabatic potential energy surfaces for an electronic hole in MgO in the presence of a Mg vacancy. At zero distortion the hole is localized on the six oxygen lattice sites surrounding the defect (the $E_g$ state) and hence, the origin of the self-trapped state is only due to the defect potential. Interaction with the lattice distortion, however, leads to the hole localization on a single oxygen lattice site (the $A_{1g}$ state). For details see paper III.

3.2.2 TiO$_2$ Bulk

Rutile and anatase TiO$_2$ are examples where an electronic hole self-traps intrinsically, i.e. only due to interaction with the lattice. The top plot in Fig. 3.4 shows adiabatic potential energy surfaces along the lattice coordinate inducing the hole localization. At zero distortion, the hole is delocalized over oxygen $p_{\perp}$
3.2 Examples

Figure 3.3: The nonadiabatic potential energy surfaces (PESs) for different symmetry states of the $V^-$ center along the $O_h(\rho = 0) \rightarrow C_{4v}$ distortion.

Orbitals forming the top of the valence band. At larger distortions, the hole localizes on a single lattice site. The bottom plot in Fig. 3.4 shows the hole state projection onto $p_\perp$ orbital of the oxygen lattice site. For details see paper I.

3.2.3 TiO$_2$ Surface

In surface layers the self-trapping strength is modified due to a potential variation induced by the crystal termination. Fig. 3.5 illustrates self-trapping strength and the electrostatic energy depth profile for the anatase (101) facet. Clearly, surface potential can significantly modify trapping strength and give rise to self-trapped states even if the electron-lattice interaction alone is insufficient for the formation of trapped states. For details see paper II.
Figure 3.4: Hole self-trapping in TiO$_2$. Top: adiabatic potential energy surfaces; bottom: charge localization on the oxygen $p_{\perp}$ orbital of the oxygen lattice site surrounded by the distortion.

Figure 3.5: Hole trapping in anatase (101) surface layers. Trapping strength $\varepsilon_T$ is modified due to the variation of the surface electrostatic potential. $U$ is the interaction energy of the hole with the surface electrostatic potential.
Accurate description of charge localization/delocalization processes is one of the biggest challenges of DFT approximations [54–63]. In particular application of DFT to small polaron problem often leads to qualitatively incorrect results [36–40]. This failure is largely a consequence of an incorrect, nonlinear behaviour of total energies in fractional electron number segments [64–71].

This chapter begins with a brief discussion of the origin of the total energy nonlinearity and demonstrate how the nonlinearity can lead to large systematic errors in description of states with different degrees of localization. Sections two and three examines the consequences of the error for the description of small polarons and provide a simple, ad hoc, solution with a few illustrative examples. Finally, the last section lists some of the methods that attempt to improve approximate DFT energies for fractional electron systems.

4.1 Origin and effects

The exact DFT energy is linear in fractional electron number segments [46, 72], see also Sec. 2.1.1. Approximate XC functionals violate this exact behaviour
and provide nonlinear total energies due to incorrect description of exchange-correlation hole $\rho_{xc}(\vec{r}, \vec{r}')$ for systems with fractional electron number [73, 74]. For instance (semi)local XC functionals provide convex curves—total energies are too low between integer electron numbers (see Fig. 4.1). This energy underestimation has been explained as a result of an incorrect sum rule for the exchange-correlation hole. The exchange-correlation hole for (semi)local XC functionals integrates to -1 which is a correct value only for an integer electron number (see Sec. 2.2.1). For open systems with fractional electron number, the exact exchange hole should integrate to a value smaller than -1. Therefore the semi-local exchange correlation energy

$$E_{xc}[\rho(\vec{r})] = \frac{1}{2} \int \rho(\vec{r}) \frac{\rho_{xc}(\vec{r}, \vec{r}')}{|\vec{r} - \vec{r}'|} d\vec{r} d\vec{r'},$$

(4.1)

is too negative at fractional electron number leading to convex total energy curves.

![Figure 4.1: A total energy as a function of electron number. The exact energy (blue line) is linear in integer electron number segments. Semi-local XC functionals provide convex total energy curves (black line). Dashed line denotes a tangent to the semi-local total energy curve at $N_+$ and $\alpha$ is the energy nonlinearity.](image)

The nonlinearity of the total energy leads to systematic errors which depend on the degree of charge localization. To illustrate this let us consider a single atom with energy

$$E(N + \lambda) = \alpha \lambda^2 + [E(N) - E(N + 1) - \alpha] \lambda + E(N),$$

(4.2)

in $[N, N + 1]$ electron number segment; $E(N)$ and $E(N + 1)$ are correct energies at $N$ and $N + 1$ electron numbers, respectively; and $\alpha$ is a quadratic energy
4.2 Nonlinearity removal

Nonlinearity (see Fig. 4.1). Adding a single electron to a system composed of $K$ noninteracting $N$ electron atoms should increase the energy by $E(N+1) - E(N)$. For $\alpha \neq 0$ however, the total energy increase is

$$\Delta E = \alpha \left[ \frac{1}{M} - 1 \right] + E(N+1) - E(N),$$

(4.3)

where the additional electron delocalizes over $M$ atoms. Solutions for $M \in \{1, \ldots, K\}$ should be degenerated, however, for $\alpha < 0$ (convex functionals) the delocalized solution $M = K$ has the lowest energy, whereas for $\alpha > 0$ (concave functionals) the localized solution $M = 1$ is the most stable.

$M$ dependent part of the energy change is quadratic in fractional electron number $\lambda$:

$$\Delta E(\lambda) = \left\{ \alpha \left[ \frac{\lambda}{M} - 1 \right] + E(N+1) - E(N) \right\} \lambda.$$  

(4.4)

Thus $\alpha/M$ can be calculated as the quadratic nonlinearity of $\Delta E(\lambda)$. Removal of $\alpha/M$ from Eq. 4.3 renders the equation $M$ independent. Such correction then allows for an unbiased comparison of energies of states with a different degree of localization.

4.2 Nonlinearity removal

Quadratic nonlinearities of total energies of noninteracting atoms translate into linear dependencies of onsite energies in a single band model presented in Sec. 3.1.2. A nonzero $\alpha$ will shift the eigenvalues of the lattice Hamiltonian (see Eq. 3.16) by the value dependent on the degree of localization of the eigenstate

$$\frac{\alpha}{M} = \frac{\alpha \sum_n |\langle n|\Psi \rangle|^4}{\left[ \sum_n |\langle n|\Psi \rangle|^2 \right]^2},$$

(4.5)

where $|\langle n|\Psi \rangle|^2$ is the occupation of site $n$ in solution $|\Psi \rangle$. For a free state ($|\Psi \rangle = |k\rangle \ M \rightarrow \infty$; for a localized state ($|\Psi \rangle = |0\rangle$) $M = 1$. Therefore the comparison of energies of the two states is burden with error $\alpha$. By removing the total energy nonlinearity $\alpha/M$, a more consistent description of the charge localization can be achieved.

Such an a posteriori correction obviously does not affect the eigenstates $|\Psi \rangle$. A nonzero $\alpha$ will have the strongest effect on the localized wave function. In zeroth order the localized state on site $0$ can expressed as

$$|0\rangle' = |0\rangle + \sum_n \frac{t_{n0}}{\Delta + DQ_0 - \alpha} |n\rangle,$$

(4.6)
where \( t_{n0} \) is the coupling between site 0 and \( n \); and \( \Delta + DQ_0 > 0 \) is the trapping energy at site 0. Positive and negative \( \alpha \) will therefore provide too delocalized and localized solutions, respectively.

### 4.3 Examples

#### 4.3.1 Polaronic defect states

Defects states of a magnesium vacancy in MgO provide a clear illustration of \( 1/M \) dependence of the localization/delocalization error. The defect states are largely formed from six oxygen \( p \)-like orbitals \( |\gamma_i\rangle \) pointing toward the vacancy.

At the \( O_h \) symmetry (the symmetry of the Mg lattice site in the perfect MgO crystal) the defect states are

\[
\begin{align*}
A_{1g} &= (|\gamma_0\rangle + |\gamma_1\rangle + |\gamma_2\rangle + |\gamma_3\rangle + |\gamma_4\rangle + |\gamma_5\rangle)/\sqrt{6} \\
T_{1u}^1 &= (|\gamma_0\rangle - |\gamma_5\rangle)/\sqrt{2} \quad T_{1u}^2 = (|\gamma_1\rangle - |\gamma_3\rangle)/\sqrt{2} \\
T_{1u}^3 &= (|\gamma_2\rangle - |\gamma_4\rangle)/\sqrt{2} \\
E_g^1 &= (|\gamma_1\rangle - |\gamma_2\rangle + |\gamma_3\rangle - |\gamma_4\rangle)/\sqrt{4} \\
E_g^2 &= (2|\gamma_0\rangle - |\gamma_1\rangle - |\gamma_2\rangle - |\gamma_3\rangle - |\gamma_4\rangle + 2|\gamma_5\rangle)/\sqrt{12} \\
\end{align*}
\]

whereas at the \( C_{4v} \) symmetry (the symmetry of the relaxed \( V^- \) center) these are

\[
\begin{align*}
A_1^1 &= |\gamma_0\rangle \quad A_1^2 = (|\gamma_1\rangle + |\gamma_2\rangle + |\gamma_3\rangle + |\gamma_4\rangle)/\sqrt{4} \\
A_1^4 &= |\gamma_5\rangle \quad B_2 = (|\gamma_1\rangle - |\gamma_2\rangle + |\gamma_3\rangle - |\gamma_4\rangle)/\sqrt{4} \\
E_1^1 &= (|\gamma_1\rangle - |\gamma_3\rangle)/\sqrt{2} \quad E_1^2 = (|\gamma_2\rangle - |\gamma_4\rangle)/\sqrt{2} \\
\end{align*}
\]

The degree of localization of these states equals to \( f = 1/M \in \{1, 1/2, 1/4, 1/6\} \).

For instance \( f = 1/6 \) for the \( A_{1g} \) state as this state is delocalized over six sites.

Fig. 4.2 shows the total energy nonlinearities for the different states. Clearly, the nonlinearities follow \( 1/M \) behaviour.

Fig. 4.3 shows potential energy surfaces of defect states calculated with the PBE XC functional (top panel); and results corrected for the energy nonlinearity (the bottom panel). The two predictions provide qualitatively different behaviours. The PBE calculated states are not only shifted but also incorrectly ordered. For details see paper III.
Figure 4.2: The energy nonlinearity $\alpha f$ follows $f = 1/M$ trend; $f$ is the degree of state localization, e.g. $f = 1/2$ for the $T_{1u}$ as this state is localized over two sites. The inset plot shows the energy nonlinearity along the $O_h(\rho = 0) \rightarrow C_{4v}$ distortion.

Figure 4.3: The nonadiabatic potential energy surfaces (PESs) for the different symmetry states of the $V^-$ center along the $O_h(\rho = 0) \rightarrow C_{4v}$ distortion. Top: PBE PESs not corrected for the delocalization error; Bottom: PESs corrected by removal of the energy nonlinearity $\alpha f$. Full lines denote states involved in optical transitions of the center; arrows tangent to the $A_{1g}$ are proportional to sum over Hellman-Feynman forces.
4.3.2 Barrier height

Another example where the incorrect description of total energies leads to qualitatively incorrect behaviours is a charge transfer process. Let us consider an electron transfer between two centers $L$ and $R$

\[
\begin{align*}
\text{Initial} & : L^1 + R \\
\text{Transition} & : L^{1/2} + R^{1/2} \\
\text{Final} & : L + R^1
\end{align*}
\] (4.7)

\[
\begin{align*}
L^1 + R & \rightarrow L^{1/2} + R^{1/2} \rightarrow L + R^1
\end{align*}
\] (4.8)

For the initial and final states $M = 1$, whereas at the transition state $M = 2$. Therefore if $\alpha$ is the nonlinearity of the total energy at a single site $R$ and $L$, the energy at the transition point is depleted by $\alpha/2$.

Fig. 4.4 shows PESs for a charge transfer between two equivalent sites. A nonzero $\alpha$ leads to characteristic kink around the transition state. For details see paper II.

Figure 4.4: Top: the PESs for the two state model for a charge transfer between two equivalent sites coupled to the lattice coordinate $x$ (full lines) and the deformed PESs due to $\delta N$ convexity of the energy of single site (dashed lines). Bottom: the charge localization on L site.
4.4 Other approaches

4.3.3 Self trapping

Charge self-trapping in extended systems is the process where the localization/delocalization error reaches its maximum. For the delocalized state $M \to \infty$, whereas for the localized one $M = 1$. Paper I, analysis an electronic hole self-trapping in TiO$_2$. The semi-local RPBE XC functional [75] predicts localized hole state to be unstable. Removal of the total energy nonlinearity leads to a stable self-trapped state (see Fig. 3.4).

4.4 Other approaches

- **Range separated hybrid schemes** such as HSE XC functional [67, 76]: These functionals incorporate a portion of the exact exchange from the Hartree-Fock theory. The improvement of the description of fractional electron systems relies on the cancellation of the $\delta N$ convexity of a (semi)local DFT by the $\delta N$ concave Hartree-Fock energy. So far, none of the mixing schemes have been able to recover the $\delta N$ linearity universally.

- **Scaling Correction** [77]: This is an interesting recent development based on an observation that the only terms that are nonlinear in the electron density are Coulomb, exchange and correlation terms. By linearizing Coulomb and exchange terms with respect to fractional electron number so that the correction is zero at integer electron numbers largely linear the total energy curves are obtained. More studies are however necessary to reveal to which extent the method can be applied to more general problems such as the discussed defect states of the $V^-$ center in MgO.

- **Non-Koopmans correction** [78]: This technique imposes the Koopmans condition, i.e. linearity of the total energy with respect to the change of the occupations of the Kohn-Sham states, by fixing eigenvalues around a chosen reference point. The method needs to be tested for its ability to deal with charge localization and delocalization processes. Since the error of the eigenvalues changes with their degree of localization, the choice of the reference points is nontrivial.

- **DFT+U** based techniques [79]: In a rotationally invariant formulation [80], the total DFT+U energy is

$$E^{\text{DFT+U}} = E^{\text{DFT}} + \frac{U}{2} \sum_{a,\sigma} \text{Tr} [n_a^\sigma (1 - n_a^\sigma)], \quad (4.9)$$
where $n_a^\sigma$ is the atomic density matrix due to the atom $a$ and the spin $\sigma$ and where $U$ is a parameter. The correction is quadratic in atomic density matrix, therefore, in principle, it can account for the spurious quadratic energy nonlinearity [81]. Since there is a certain degree of arbitrariness in definition of atomic density matrices, and they do not necessarily follow linearly the change in electron number a single $U$ may not suffice for a complete removal of energy nonlinearities.

- Non-local external potential [39]
  This DFT+$U$ like method has been specifically formulated for the problem of polaronic hole localization. Since different $U$ values are required for a correct description of a host band structure and a localized hole state, a nonlocal potential is constructed so that it affects the localized hole state only.

- DFT+$U+V$ [82, 83]
  DFT+$U$ is extended by introduction of an inter-site parameter $V$. Both $U$ and $V$ are calculated internally based on linear response.

- Perdew-Zunger self-interaction correction [84, 85]
  The method improves the description of the exchange-correlation hole by removing the orbital electron self-interaction. This correction however, only partially removes the total energy nonlinearity and worsens equilibrium properties [86].
Small Polaron Optical Absorption

Time resolved optical spectroscopies are the most commonly used techniques to monitor the dynamics of the photo generated charge carriers. To exploit the full wealth of information these techniques provide, one first has to understand the physical origins of the optical absorption bands.

In this Chapter DFT is applied to small polaron optical absorption. The first section analyzes the origin of small polaron optical transitions. Section two provides absorption coefficient for vibronic transitions and briefly discusses assumed approximations. In the last section, DFT is applied to optical absorption of the $V^-$ center in MgO and to the bulk and surface self-trapped holes in TiO$_2$.

5.1 Interpolaron transitions

Small polarons have strong absorption features due to optical charge transfer transitions i.e., promotions of the electron (hole) trapped on one site to one of the neighboring sites (interpolaron transitions) [87–90]. This concept is illustrated in Fig. 5.1. A carrier localized on site $L$ is promoted to site $R$. The transition
Figure 5.1: Promotion of a small polaron localized on site $I$ to a neighboring site $F$ (inter-polaron transition). The transition is vibrionic as it involves simultaneous change of the electron state and nuclear quantum numbers.

involves simultaneous change of electronic state and nuclear quantum number—has a vibrionic character.

## 5.2 Absorption coefficient

The optical absorption coefficient $k(\omega)$ is defined through Beer-Lambert law:

$$I(\omega, z) = I(\omega, 0) \exp(-k(\omega)z),$$  \hspace{1cm} (5.1)

where the light of initial intensity $I(\omega, 0)$ is attenuated along the direction of the propagation $z$ and $\omega$ is the light angular frequency. When the absorption occurs due to distinct centers such as defects, it is convenient to define absorption cross-section per center:

$$\sigma(\omega) = k(\omega)/N,$$  \hspace{1cm} (5.2)

where $N$ is the number of centers. Absorption cross-section can be derived from quantum mechanical description of transition probability between two states induced by coupling to the radiation. The transition rate is

$$W = \frac{2\pi}{\hbar^2} |\langle i|V|f \rangle|^2 \delta(\omega - \omega_{if}),$$  \hspace{1cm} (5.3)

where $V$ is the coupling operator; and $i, f$ are the initial and the final states, respectively.
5.2 Absorption coefficient

5.2.1 Vibrionic Transitions

In the derivation of the absorption cross-section for the vibrionic transitions usually three approximations are employed [91, 92]:

1. Born-Oppenheimer approximation breaks the wave-function into the product of an electronic and a nuclear part:
   \[ i(r, Q) = I(r; Q)\chi(Q), \tag{5.4} \]
   where the electronic part \( I(r; Q) \) depends parametrically on the nuclear coordinate \( Q \).

2. Condon approximation: \( \langle I|V|F \rangle \) is independent on \( Q \).

3. Dipolar approximation: only electric dipole moment transitions are involved.

The application of the above approximations leads to the absorption cross-section: \(^1\)

\[ \sigma(\omega) = \frac{2\pi e^2 \hbar}{m} f_{IF} G_{IF}(\omega), \tag{5.5} \]

where \( G_{IF} \) is the shape function and \( f_{IF} \) is the oscillator strength. The shape function takes the form:

\[ G_{IF}(\omega) = A_v \sum_{\beta} |\langle \alpha|\beta \rangle|^2 \delta(\omega_{IF} + \omega_{\alpha\beta} - \omega), \tag{5.6} \]

where \( A_v \) denotes thermal average over initial states and the sum runs over final states. \( G_{IF}(\omega) \) is normalized to unity over \( \omega \).

The oscillator strength is a dimensionless quantity:

\[ f_{IF} = \frac{2m\omega_{IF}}{e^2 \hbar} \bar{\mu}_{IF}^2, \tag{5.7} \]

where \( \bar{\mu}_{IF} \) is the electronic transition dipole moment. \( f_{IF} \) expresses the strength of the transition and satisfies the sum rule \( \sum_{F} f_{IF} = 1 \).

5.2.2 Transition Dipole Moment

The transition dipole moment between the initial \( |I\rangle \) and final \( |F\rangle \) states equals

\[ \bar{\mu}_{IF} = \langle I| - e\vec{r}|F \rangle. \tag{5.8} \]

\(^1\)For the effective field and the difference in the velocity of light propagation in a material medium corrections see [93].
If the states $|I\rangle$ and $|F\rangle$ are associated with transnationally equivalent sites $R$ and $L$, respectively, their first order expansions take the forms:

$$|I\rangle = |L\rangle + \frac{t}{\hbar\omega_{IF}} |R\rangle,$$

(5.9)

$$|F\rangle = |R\rangle - \frac{t}{\hbar\omega_{IF}} |L\rangle,$$

(5.10)

where $|R\rangle$ and $|L\rangle$ are orthonormal wave-functions associated with noninteracting sites $R$ and $L$, respectively; $t$ is the electron coupling between the two sites; and $\hbar\omega_{IF}$ is the transition energy (see Fig.5.1). Inserting Eq.5.9 and Eq.5.10 to Eq.5.8 and using translational equivalence between sites $R$ and $L$:

$$R(\vec{r}) = L(\vec{r} + \vec{p}),$$

(5.11)

where $\vec{p}$ is the vector connecting the two sites, $\vec{\mu}_{IF}$ takes the final form [94]:

$$\vec{\mu}_{IF} = \frac{te}{\hbar\omega_{RL}} \vec{p}.$$  

(5.12)

### 5.3 Examples

#### 5.3.1 $V^-\text{MgO}$

The top part of Fig. 5.2 shows the experimental and calculated absorption spectra of the $V^-\text{center}$ in MgO. The optical absorption spectrum consists of a broad peak centered at $\approx 2.3$ eV and the low energy part involves hole transfer transitions between oxygen $p$-like orbitals pointing toward the vacancy$^2$ [94, 95]. In an electric field, the $V^-\text{centers}$ align and absorption of light polarized parallel ($||$) to the direction of the applied electric field has a peak at $1.85\text{eV} (A_1^1 \rightarrow A_2^1)$; whereas the absorption peak for the light polarized perpendicularly ($\perp$) is located at $2.30\text{eV} (A_1^1 \rightarrow E)$ [90, 94, 95]. The bottom part of Fig. 5.2 shows $\sigma_{||} - \sigma_{\perp}$. For defect states and associated PES see Sec.4.3.1 or paper III.

#### 5.3.2 Self-trapped hole in TiO$_2$

The shaded bands in Fig. 5.3 show the calculated optical absorption of the self-trapped holes in anatase. The band $X$ is due to the holes trapped in the

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$^2$The high energy part involves also transition for other $p$ orbitals surrounding the vacancy.
5.3 Examples

Figure 5.2: Top: the optical absorption spectra of the $V^-$ center. Bottom: the dichroism curve. Dotted and full lines denote the experimental data [95] and calculated bands, respectively. Shaded areas denote transitions due to the perpendicular ($\perp$) and parallel ($\parallel$) light polarization.

bulk, whereas bands $Y_1$, $Y_2$, $Y_3$, $Z$ are due to the most stable (sub)surface hole trapping sites, see Fig. 5.4 for the locations. Transition energies form the surface trapped holes are at higher energies than form the bulk trapped holes. This is largely because in surface layers trapping strength oscillates (see section 3.2.3) and an additional energy is needed to optically transfer hole to neighboring trapping sites ($\Delta$ on Fig. 5.1). For details see paper V.
Figure 5.3: The optical absorption spectra of the self-trapped holes in anatase TiO$_2$. The absorption energy increases with the increase in stability of the hole state relative to its neighbours. Bands: $X$—bulk holes; $Y_1$, $Y_2$, $Y_3$—holes in (101) surface layers; $Z$—hole on (001) surface. Lines denote experimental measurements: full line [23]; dashed line [96]; dash-dotted line [96]; dotted line [28].

Figure 5.4: Location of trapping centers $X$, $Y_1$, $Y_2$, $Y_3$, $Z$. Arrows indicate the strongest transitions. Letters $A$ – $E$ denote distinct charge transfer paths in the anatase bulk, and accompanied numbers denote nonequivalence of paths in surface layers.
Chapter 6

Small Polaron Mobility

Delivery of photogenerated carriers to surface reactive sites is a crucial step in any photocatalytic process. Transport of electrons and holes should not be a limitation for reaction kinetics.

This Chapter first introduces the concept of electron mobility. The next two sections describe the two possible charge transport mechanisms in semiconductors: 1) band conduction and 2) small polaron hopping. Finally, the last section discusses hole transport in TiO$_2$.

6.1 Electron Mobility

A phenomenological description of electron conductivity is expressed in Ohm’s law: the current density $\vec{j}$ at a given location in a conductor is proportional to the applied electric field $\vec{E}$ at that location

$$\vec{j} = \sigma \vec{E},$$

where the electronic conductivity $\sigma$ is material dependent second rank tensor. For the sake of simplicity, in the following, I consider isotropic conductivity i.e. $\sigma$ to be a scalar quantity and $\vec{j} \parallel \vec{E}$. 
The accelerating force $-eE$ acting on charge carriers in a material is counter-balanced by scattering processes, therefore $\sigma$ has a finite value. Defining $\tau$ as the mean electron time, the electron conductivity can be expressed as

$$\sigma = \frac{n e \tau}{m^*} = n \mu, \quad (6.2)$$

where $n$ is the carrier density and $m^*$ is the electron effective mass. The electron mobility $\mu$ characterises motion of a single electron in a material i.e., is the drifted velocity $v_d$ in a unit electric filed $E$:

$$\mu = \frac{v_d}{E}. \quad (6.3)$$

### 6.2 Band Transport

This section provides a basic introduction to the band transport mechanism. Electrons in a crystal occupy Bloch states labeled by crystal momentum quantum number $k$. The electric conductivity is therefore a sum over all contributions arising from occupied $k$ states. Using definition in Eq. 6.1, $\sigma$ takes the form

$$\sigma = \frac{j}{E} = \frac{e}{E V} \sum_k v(k) F(k), \quad (6.4)$$

where $V$ is the crystal volume, $F(k)$ is the Fermi-Dirac distribution in the applied electric field $E$ and

$$v = \frac{1}{\hbar} \frac{d \varepsilon(k)}{dk} \quad (6.5)$$

is the group velocity of the electron particle-wave in energy band $\varepsilon(k)$.

In electric field $E$, the electron acceleration increases crystal momentum $\hbar k$:

$$\hbar \frac{dk}{dt} = -eE. \quad (6.6)$$

Due to scattering processes however, the shift of the Fermi distribution $F(k) \approx f(k + \Delta k)$ saturates at some finite $\Delta k$:

$$\Delta k \approx -\frac{eE \tau}{\hbar}, \quad (6.7)$$

where $\tau$ is the mean free electron time and $f(k)$ is the Fermi-Dirac distribution at zero field. Expanding the Fermi-Dirac distribution in the first order in $\Delta k$

$$f(k + \Delta k) = f(k) + \frac{df(k)}{dk} \Delta k, \quad (6.8)$$
and performing simple arithmetic manipulations, the electron conductivity is found to be

$$\sigma = \frac{e\tau}{V} \sum_k \left[ \frac{d^2\varepsilon}{\hbar^2dk^2} \right] f(k).$$  \hspace{1cm} (6.9)

Defining the effective mass $$m^*$$ as

$$m^* = \left[ \frac{d^2\varepsilon}{\hbar^2dk^2} \right]^{-1}$$  \hspace{1cm} (6.10)

and carrier density $$n$$ as

$$n = \frac{1}{V} \sum_k f(k)$$  \hspace{1cm} (6.11)

we arrive to Eq. 6.2. In general, the effective mass is a second rank tensor therefore the conductivity is an anisotropic quantity.

### 6.2.1 Mobilities in Semiconductors

In semiconductors there are no states at the Fermi level and charge transport can only be realized via thermally or optically excited carriers—the electrons in the conduction band and holes in the valence band.

$$\sigma = n_h\mu_h + n_e\mu_e$$  \hspace{1cm} (6.12)

In most semiconductors, the Fermi level is well separated from the conduction and valence band edges. Thus, the Fermi-Dirac distribution approximates to Boltzmann distribution and when carriers are thermalized, their mean speed is the thermal velocity

$$<v> = \sqrt{\frac{8k_B T}{3\pi m_e}}.$$  \hspace{1cm} (6.13)

Typical band mobilities in semiconductors are $$10^{-10^4} \text{ cm}^2 \text{ V}^{-1}\text{s}^{-1}$$ at room temperatures. For instance for conduction band electrons in Si $$\mu_e = 1500 \text{ cm}^2 \text{ V}^{-1}\text{s}^{-1}$$. Using Eq.6.2, the thermal velocity at room temperature $$<v> = 10^7 \text{ cm/s}$$, and the effective mass of electrons in Si conduction band $$m_e^* = 1.18m_e$$, we find the mean free electron time $$\tau = 10^{-12} \text{ s}$$ and the mean free electron path of the electron of $$10^3 \text{ Å}$$.

### 6.3 Hopping Transport

In number of materials mobilities are smaller that $$1 \text{ cm}^2 \text{ V}^{-1}\text{s}^{-1}$$. Such low values would require unphysically short mean free electron paths of $$\sim 0.1 \text{ Å}$$. 

Furthermore the electron mobility in these materials increases with temperature which is in contrast to band transport mechanism where the mobility decreases with temperature. The mechanism explaining above observations is thermally activated hopping. Taking a hop distance of $a \sim 3 \text{ Å}$ (a typical atomic spacing in crystals) and hopping frequency $k \sim 10^{12} - 10^{13} \text{s}^{-1}$ (a typical value for phonon frequencies), one can estimate the hopping mobility at room temperature to be

$$\mu = \frac{ea^2 k}{k_B T} \sim 0.1 \text{ cm}^2 \text{V}^{-1} \text{s}^{-1}. \quad (6.14)$$

The hopping mechanism holds if the time between hops $k^{-1}$ is smaller than the residence time of an electron on transitionally equivalent lattice sites $\tau \approx t/\hbar$, where $t$ is the resonance integral related to the electron band width. Typically $t$ is of the order of 1 eV therefore $\tau \approx 4 \times 10^{-15} \text{s} \ll k^{-1}$.

Hopping transport becomes relevant under strong electron-phonon coupling when $t$ renormalizes exponentially

$$t' = t \exp(-S_T). \quad (6.15)$$

The factor $S_T$ is proportional to $\coth[\hbar\Omega / (2k_BT)]$ and the proportionality constant is related to the strength of the electron coupling to the phonon mode of angular frequency $\Omega$ [97–99]. Thus for strong electron-phonon coupling the resonance integral $t'$ becomes exponentially small at temperature:

$$T_h \gg \frac{\hbar\Omega}{2k_B}. \quad (6.16)$$

6.3.0.1 Hopping mobility

At the small polaron limit i.e., when the electron is confined to a single lattice site, the hopping is limited to the neighboring sites [97–99]. Depending on the relative dynamics of the electron and the lattice, two limiting situations can be distinguished:

- The adiabatic limit—the electronic motion is much faster than the nuclear and the system remains on a single PES. The charge transfer proceeds via thermally activated barrier crossing.
- The nonadiabatic limit—the electron does not follow the fast nuclear dynamics and transitions occurs via tunneling at the cross-section of two nonadiabatic potential energy surfaces.
For the two limits, the hopping frequency takes the form:

\[ k = \frac{\Omega}{2\pi} e^{-\frac{E_b}{2k_BT}} \times \begin{cases} 
1 & \text{for } \eta_2 > 1, \text{ adiabatic limit} \\
\frac{\pi^{3/2}}{2\eta_2} & \text{for } \eta_2 \ll 1, \text{ nonadiabatic limit} 
\end{cases} \]  

(6.17)

Where

\[ \eta_2 = \frac{t^2}{\hbar\Omega\sqrt{E_a k_BT}} \]  

(6.18)

describes relative dynamics of the electron and the lattice systems [97–99].

### 6.4 Example

Fig. 6.1 shows PES for the different hole transfer paths between neighboring oxygen lattice sites in TiO$_2$. The single effective atomic nuclear coordinate is defined as a linear interpolation between the final and the initial geometries for the hole transfer. The effective mode energies along the coordinate are \( \approx 0.04 \) and \( \approx 0.02 \) eV for rutile and anatase, respectively. Therefore according to Eq. 6.16 hopping is a relevant mechanism at temperatures above \( \sim 230 \) and \( \sim 120 \) K for rutile and anatase, respectively.

Figure 6.1: Potential energy surfaces for hole transfer paths between neighboring oxygen lattice sites in TiO$_2$. 

---

*Note: The diagram shows potential energy surfaces for hole transfer paths between neighboring oxygen lattice sites in TiO$_2$. The figure illustrates the energy changes \( \Delta E \) as the coordinate \( \text{Coordinate} \) varies from -0.6 to 0.6.*
Using Einstein-Smoluchowski relation between the mobility $\mu$ and the diffusion coefficient $D$:

$$\mu = \frac{eD}{k_B T}$$

(6.19)

and Eq. 6.17 and 6.18, the averaged hopping mobility takes the form

$$D = \sum_{i \in A} n_i k_i |R_i|^2 / 3,$$

(6.20)

where $n_i$ is a number of equivalent paths, $k_i$ is the transfer frequency, $|R_i|$ is the transfer distance, and the summation is over nonequivalent hole transfer paths. For details see paper II.
Photogenerated charge carriers (electrons and holes) play a central role in any photocatalytic process [6, 100]. In TiO$_2$ the holes trap, but the nature of trapping sites as well as effects of trapping on photocatalytic performance are unclear.

This chapter first summarises the properties of TiO$_2$ that are relevant to the photocatalytic processes. The second section discusses possible effects of charge trapping on a photocatalyst performance. Finally, the third section discusses hole trapping in TiO$_2$.

### 7.1 Properties of TiO$_2$

#### 7.1.1 Structural

The two main polymorphs of TiO$_2$ are rutile (D$_{4h}^{14}$-P4$_2$/mmm, $a = 4.584$ Å, $c = 2.953$ Å) and anatase (D$_{4h}^{19}$-I4$_1$/amd, $a = 3.782$ Å, $c = 9.502$ Å)[101, 102]. Both crystal forms are tetragonal and their basic building block is a deformed TiO$_6$ octahedron (see Fig. 7.1) and the deformation is larger in anatase. A
characteristic feature of both structures is a planar first coordination shell of oxygen sites—a $C_2v$ symmetric OTi$_3$ unit. Such coordination is achieved by sharing each vertex of the TiO$_6$ octahedron with two other octahedra: in rutile through one edge- and one corner-type connection (see Fig. 7.1(a)); in anatase through two edges (see Fig. 7.1(b)).

Bulk rutile is the stable phase of TiO$_2$ under pressures below $\sim$ 10GPa [103–105]. Anatase becomes stable for nano-particle sizes smaller than $\sim$ 14 Å [106] due to lower surface energies as well as smaller destabilization effects of corners and edges [107].

Tab. 7.1 shows surface energies of rutile and anatase facets in vacuum. For rutile the most stable is the (110) surface whereas for anatase it is the (101) surface. In a nonvacuum environment surface stability changes. For instance, for anatase in solutions containing F$^-$ anions the (001) surface becomes more stable than the (101) [108–111].

<table>
<thead>
<tr>
<th></th>
<th>Calculated$^a$</th>
<th>Reference</th>
</tr>
</thead>
<tbody>
<tr>
<td><strong>Rutile</strong></td>
<td></td>
<td></td>
</tr>
<tr>
<td>(110)</td>
<td>not converged</td>
<td>$0.48^b$, $0.31^d$, $0.69^d$, $0.47^f$</td>
</tr>
<tr>
<td>(100)</td>
<td>$0.66$</td>
<td>$0.67^b$, $0.60^f$</td>
</tr>
<tr>
<td>(011)</td>
<td>$1.11$</td>
<td>$1.01^b$, $1.12^d$, $0.95^f$</td>
</tr>
<tr>
<td>(001)</td>
<td>not converged</td>
<td>$1.21^b$,</td>
</tr>
<tr>
<td><strong>Anatase</strong></td>
<td></td>
<td></td>
</tr>
<tr>
<td>(101)</td>
<td>$0.45$</td>
<td>$0.41^c$, $0.44^d$, $0.41^e$, $0.35^f$</td>
</tr>
<tr>
<td>(100)</td>
<td>$0.76$</td>
<td>$0.53^d$, $0.51^e$, $0.39^f$</td>
</tr>
<tr>
<td>(001)</td>
<td>$1.04$</td>
<td>$0.96^e$, $0.90^d$, $0.96^e$, $0.51^f$</td>
</tr>
</tbody>
</table>

$^a$ RPBE, PAW  
$^b$ [112]  
$^c$ [111]  
$^d$ [113, 114]  
$^e$ [107]  
$^f$ [105]
7.1 Properties of TiO$_2$

Figure 7.1: TiO$_2$ structures. Each vertex of the TiO$_6$ octahedron is shared with two other octahedra: in rutile through one corner- and one edge-type conductions; in anatase through two edge-type conductions.

### 7.1.2 Electronic and optical

TiO$_2$ is an $n$-type semiconductor\(^1\) and the excess electrons originate from oxygen under-stoichiometry:

\[
2O_O \rightarrow O_2 + 2V_O^{2+} + 4e^-.
\]  

(7.1)

Apart from oxygen vacancies ($V_O$) in various charge states, titanium interstitial (Ti$_i$) and vacancies ($V_{Ti}$) as well as more complex defects have been reported [115–117].

---

\(^1\)High oxygen pressures could transform TiO$_2$ to a $p$-type semiconductor. Such material, however, has not been yet reported.
Both phases have similar electronic structure. The valence band is due to oxygen $p$ states and its edge is formed from $p$-like orbitals perpendicular to the planar OTi$_3$ unit. The conduction band is due to titanium $d$ states, and it is split into the $e_g$ and $t_{2g}$ symmetric components. (For the projected density of states onto atomic orbitals see paper I.)

The experimental optical band gaps in rutile and in anatase are 3.0 eV [118] and 3.3 eV [119], respectively. In rutile the direct and indirect band gaps are very close, the latter being 0.04 eV lower in energy (GW calculations); in anatase the band gap is indirect [120]. A characteristic feature of anatase optical absorption is an exponential increase of the absorption with the photon energy (Urbach tail) what suggests strong exciton effects [121].

### 7.2 Photocatalysis

Semiconductor photocatalysis is a process of accelerating a photochemical reaction by transferring photon energy to reactants via photogenerated electron-hole pairs in a semiconductor. Most of photocatalytic processes are electrochemical transformations. Photocatalyst there plays a role of a photoelectrode—photocathode for reduction half reaction:

$$\text{Ox1} + e^- \rightarrow \text{Red1},$$

(7.2)

photoanode for oxidation half reaction:

$$\text{Red2} + h^+ \rightarrow \text{Ox2}.$$  

(7.3)

Product formation at standard conditions (temperature $T = 298$ K, pressure $p = 1$ bar) and unit activities requires the electrochemical potential of the electron (hole) to be lower (higher) than the standard electrochemical potential of the respective half-reaction (see Fig. 7.2).

Fig. 1.2 illustrates the necessary steps of a photoelectrochemical process: photogeneration of electron-hole pairs (excitons); charge separation and transfer to surface reactive sites; and electrochemical reaction. Recombinations processes as well as side and reverse reactions limit photocatalytic performance. The efficiency of photoelectrochemical transformation of absorbed photons—a quantum yield $\eta$—can be expressed as

$$\eta = \frac{\phi_P}{\phi_P + \phi_U}$$

(7.4)

where $\phi_P$ and $\phi_U$ denote productive electron-hole pair transfer rate and unproductive electron-hole pair loss rate.
7.2 Photocatalysis

Figure 7.2: Semiconductor band alignment with respect to the electrochemical potential. For the photoelectrochemical process to proceed, the electrochemical potential of the photogenerated electrons (holes) must be lower (higher) than the electrochemical potential of the redox pair.

7.2.1 Effects of Charge Trapping

As discussed in chapter 3, in number of materials excess carriers localize either intrinsically (due to a strong electron-lattice interaction) and/or extrinsically (with assistance of a defect potential). The localized nature of charge carriers strongly affects the basic steps of photocatalytic processes.

First, charge trapping decreases carrier mobility. Carrier delivery to surface reactive sites precedes a photocatalytic reaction therefore a sluggish electron and/or hole transport may limit reaction kinetics. In particular, the important component of the mobility—normal to surface—can be strongly affected in surface layers. This is because of the electrostatic potential variations near surfaces, which create additional barriers for hopping transport.

Second, the spacial and energetic distributions of trapping sites may affect charge carrier availability for the reaction and recombination processes. For high quantum yields $\eta$, the electron and the hole populations should not overlap to minimize the recombination rate and be localized on surfaces to facilitate the reaction kinetics.

Third, trapping of the photogenerated carriers lowers the free energy available for redox transformations. For reduction on photocathode (oxidation on photoanode)\(^1\) the electrochemical potential of the electrons (holes) must be lower (higher) than the standard redox potential of the respective half reaction.

Finally, charge localization influences charge transfer processes [122]. Charge trapping can have both negative and positive effects on photocatalyst

\(^1\)Product formations at standard conditions (temperature $T = 298$ K, pressure $p = 1$ bar) and unit activities.
performance. If a photochemical process is limited by the kinetics of the photochemical reaction (charge transport is fast) then surface availability of the charge carriers will be decisive. Depending on the energetic and the spacial distribution of trapping sites, charge trapping can both increase and decrease the excess carrier density on surfaces (see paper IV). On the other hand, if the photochemical process is limited by carrier transport to surfaces (the reaction kinetics is fast) then charge trapping can be regarded as unfavorable as it decreases carriers mobility.

7.3 Hole trapping in TiO$_2$

Localized hole states in photoexcited TiO$_2$ have been observed in number of experiments. In particular, solid evidence comes from electron paramagnetic resonance (EPR) measurements which detect unpaired spin density localized on oxygen atoms [12–22].

Another technique that proves a localized nature of the photogenerated holes is the transient absorption spectroscopy. The hole absorption spectra consist of broad peak, typical to vibronic transitions [23–29], whereas free carrier absorption is qualitatively different (the absorption coefficient is $\propto \omega^{-\beta}$ with $\beta \approx 2$ [123]).

Photoluminescence (PL) provides less direct evidence as PL transitions involve both the photogenerated electron and hole. The PL transitions are at sub-band gap energies therefore involve band gap states. Similarly to the absorption band, the emission band is also broad, suggesting a vibrionic nature of PL transitions [124–131].

7.3.1 Trapping sites

The atomic structure of hole trapping sites in TiO$_2$ has been difficult to resolve, and centers such as surface hydroxyls groups (–OH), surface bridging oxygen atoms (–O) or lattice oxygens (–O–) have been proposed [6].

Among them surface hydroxyls have long been considered the primary hole trapping centers. EPR experiments, however, indicate that this is not the case since the H$^1$ hyperfine coupling is too small and only weakly anisotropic, and the EPR signal only slightly shifts in D$_2$O [13, 21]. Furthermore, the occupied levels of surface hydroxyl groups are below the VB edge therefore they can not trap thermalized holes [128, 132, 133].

Nakamura et al. therefore suggested surface lattice oxygens (–O–) as primary
Hole trapping centers [128, 129, 134, 135]. This attribution, however, was disputed as inconsistent [133] with isotope labeling experiments [136].

Our calculations show that holes self-trap intrinsically on oxygen lattice sites forming O$^-$ small polarons (see paper I). The hole is localized on oxygen $p$-like orbital perpendicular to the flat OTi$_3$ unit of rutile and anatase structures (see Fig. 7.3).

In surface layers the trapping strength oscillates and converges to the bulk value within 1-2 nm below the surface. Fig. 7.4 shows energy profiles for the anatase (101) and (001) surfaces. Oscillations are larger for the (101) than for the (001) surface as the former is stacked from polar layers and the electrostatic effects determine trapping strength variations (see the bottoms panel of Fig. 7.4 for the electrostatic interaction energy $U(z)$ of the hole density localized at $z$ with the surface potential).

For most anatase and rutile surfaces the trapping strength is the largest on the bridging oxygen site (>O). Hole trapping on this site is consistent with isotope labeling experiments [132, 133, 136]. Trapping on the bridging (or the subsurface) oxygen atoms is also in accordance with a weak hyperfine H$^1$ coupling of the EPR signal for samples in H$_2$O and a small change of the signal upon replacing H$_2$O with D$_2$O [13, 21]. Since most of EPR measurements are performed using polycrystalline samples and data acquisition times are typically on the order of microseconds, the EPR signal likely originates from the most stable, surface bridging sites. Recently EPR measurements performed on a single crystal rutile, however, were able to detected O$^-$ centers with the lattice oxygen symmetry >O$-$ [14].

Figure 7.3: The hole trapping on oxygen lattice site in rutile.
Figure 7.4: Self trapping energies $\varepsilon_T$ with respect to the valence band edge for anatase {001} and {011} surfaces. In surface layers hole stabilisation energies oscillate and within 1-2 nm below the surface the profiles converge to the bulk value $\varepsilon_B^T$. Larger surface hole strapping strength on {001} facets explains their stronger oxidative reactivity compared. $U(z)$ is the overlap of the electrostatic potential $V(r)$ and the density of the hole orbital $n_p(r-z)$ centered at depth $z$. Similarity between $U(z)$ and $\varepsilon_T$ suggest that variation of trapping strength in surface layers is an electrostatic effect. The shaded area denotes the valence band.

7.3.2 Trapping strength

We have found that the $O^-$ small polaron state is 0.20 eV and 0.05 eV more stable than the delocalized hole state in anatase and rutile, respectively (see paper I). This result was obtained by correcting the energies for the inconsistent description of states with different degrees of localization (see chapter 4). Di Valentin et al. has found much larger trapping strength in anatase, 0.75 eV, using hybrid DFT [137].

A method that can access the energetics of band gap states is a photoluminescence (PL). The PL spectra of the photoexcited anatase consists of a Gaussian-shaped peak at 2.2 eV and a wide band extending to 3.4 eV (the anatase band gap energy) [124–131]. The former emission can be attributed to electron-hole recombinations involving trapped states of the hole and/or electron, whereas the latter is due to free (or shallowly trapped) carriers. It is not clear, however, if the signal originates from bulk or surface recombinations. Nevertheless, the PL at 2.2 eV is consistent with trapping strength of 0.2 eV in the bulk, trapping strength of 0.75 eV [137] would result in PL at $\approx 1.75$ eV.
7.3 Hole trapping in TiO$_2$

PL transitions from surface states should be even at lower energies. Rutile photoluminescence is located at 2.7-3.0 eV indicating week carrier trapping (3.0 eV is the rutile band gap energy). PL from the rutile (110) and (001) surface states have been detected at 1.8 eV [128–130].

7.3.3 Dynamics

Studies of dynamics of photogenerated electron-hole pairs in semiconductors require ultrafast techniques [138]. Transient absorption spectroscopy (TAS) allows to monitor carrier dynamics on a sub-picosecond time scale [139]. The method employs a short femtosecond laser pulse (pump) to generate electron-hole pairs and a second pulse (probe) to monitor the photogenerated charge carrier absorption. The spectra is a sum of the electron and the hole absorptions. By scavenging one type of carriers the spectra for the other can be can be recorded and thus both contributions resolved. For instance excess electrons in photoexcited TiO$_2$ can be removed by depositing Pt, or by suspending particle in a solution containing Ag$^+$ [23, 23–29]. Such procedure allows to attribute 450-550 nm (2.8-2.3 eV) range of the TAS spectra of TiO$_2$ to the trapped hole absorption [25–27, 29, 140].

The time evolution of photoexcited TiO$_2$ TAS spectra is characterised by several time scales. After the excitation the absorption spectra has free electron character that disappears due to trapping. Trapping time is longer at higher energies and takes 50-200 fs [26, 141–143]. The absorption then blue shifts within 1-3 ps to 550 nm (2.3 eV) [26, 29, 142, 144] and then to 450 nm (2.8 eV) within the next 20-100 ps [25–27, 29, 140]. The shape then remains unchanged on nanosecond time scale [24–27, 29, 140, 145].

Section 5.3.2 and paper V discusses the interpolaronic transitions of self-trapped holes in anatase. Positions of optical absorption bands depend on the location of trapping sites. Holes that are trapped in the bulk absorb light at 650 eV, whereas those trapped in surface layers absorb at higher energies. For holes trapped in the first, second, and third surface layer of anatase (101) surface the optical absorption bands peak at 400 nm, 470 nm, 520 nm, respectively, whereas for (001) surface at 350 eV. Thus the experimentally observed blue shift of the hole absorption spectra on a picosecond time scale can be associated with the hole transfer to surfaces. This interpretations is also consistent with experimental measurements of a picosecond hole transfers from photoexcited TiO$_2$ to SCN$^-$ [96] or aliphatic alcohols [25].

Basing on this assignment, the time evolution of absorption spectra can be linked to the hole transfer toward surfaces. First, the longer trapping time at higher energies could be because of a delay time for free holes to reach the surface. Second, the change of the spectra withing 1-3 ps can be linked to hole transport after the trapping. This fast transport can not be explained with the hopping
Figure 7.5: Surface hole trapping strength $\varepsilon_S^T$ plotted against the work functions $\phi$. Shaded area denotes the valence band whereas dashed lines are the bulk self-trapping strengths $\varepsilon_B^T$ for rutile and anatase.

mechanism as a single hop would take a similar time (Eq. 6.17 and barrier height of 0.1 eV, $h\Omega = 40$ meV, $T = 300$ K results in a hoping frequency $1/8$ ps$^{-1}$). If holes are not too deeply trapped, however, thermally excited holes could account for this fast transport.

Third, 20-100 ps shift of the spectra from 550 nm to 450 nm surface is likely due hoping transport of deeply trapped holes in surface layers.

7.3.4 Effects on photocatalysis

A picosecond hole delivery to surface reactive sites should not be a limitation for reactions occurring on a longer time scale such as a microsecond hole transfer to toluene or acetonitrile [146] or millisecond-second water oxidation and oxygen evolution [28]. For slow reactions, charge trapping may reveal itself through its effect on excess charge distribution (see section 7.2.1) as the reactions rate depends on surface excess carrier concentration. For anatase and rutile surfaces hole trapping strength on surface sites vary significantly (up to $\approx 1$ eV), see Fig. 7.5, and increases in the following order: for rutile $\{100\}<\{110\}<\{011\}<\{001\}$; and for anatase $\{011\}<\{100\}<\{001\}$). Therefore there is a large thermodynamic driving force for an uneven distribution of the excess hole density among different facets.

Different reaction rates for the different TiO$_2$ facets have been indeed observed. For instance Pb$^{2+}$ oxidation (PbO$_2$ deposition) [147–149] as well as anodic phototetching in H$_2$SO$_4$ [150] rates vary among rutile and anatase facades and the
oxidation rate increases with the surface hole trapping strength. These reaction are likely to be slow as they involve significant nuclear rearrangements.
TiO$_2$ photocatalyst
In the present thesis has been studied the localized nature of photogenerated holes in TiO$_2$. It has been found that the holes self-trap on oxygen lattice sites forming O$^-$ small polarons and anatase offers stronger hole trapping centers than rutile.

In surface layers the trapping strengths oscillate around the bulk value due to the electrostatic potential variation induced by crystal termination. For most surfaces the deepest hole traps are provided by bridging oxygen sites (>O).

Furthermore, trapping strength vary among different rutile and anatase facades and surface hole stability increases in the following order: for rutile \{100\} < \{110\} < \{011\} < \{001\}; and for anatase \{011\} < \{100\} < \{001\}. This variation provides a large thermodynamic driving force (up to \approx 1 eV) for an uneven distribution photogenerated holes among rutile and anatase facades, thus affects the hole availability for photoanodic oxidation reactions. For instance the calculated hole stability order positively correlates with experimental PbO$_2$ photodeposition and the anodic photoetching rates.

The assignment of the trapped hole optical absorption bands to interpolaronic (charge transfer) transitions has allowed to link the blue shift of TiO$_2$ transient absorption spectra to the trapped hole transfer towards surfaces. Different time scales of the hole dynamics, however, need to be clarified. In particular, hole transport in surface layers should be addressed in more detail.

Many unexplained aspects of TiO$_2$ photocatalysis, such as photoinduced hydrophilicity and large amount of experimental data renders this material partic-
ularly good subject for computational study. Furthermore, TiO$_2$, an abundant material, has a technological advantage, especially since many materials become scarce. Increasing capabilities for materials nano-structuring can lead to new functionalities. Here a good example is TiO$_2$ based memristor—a memory element first envisioned in 1971 but developed only in 2008 [151].

In addition, this thesis has dealt with the problem of a biased treatment of states with different degrees of localization. It has been shown that a more consistent comparison of energies of such states can be achieved by removing the total energy nonlinearity. This a posteriori correction has been applied to number of cases, and resulted in improvement of otherwise qualitative incorrect results. The study of charge localization/delocalization processes with DFT, however, remains a big challenge, and a development of new XC functionals that can more accurately account for fractional electron systems is needed.
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Electronic hole localization in rutile and anatase TiO$_2$ – Self-interaction correction in $\Delta$-SCF DFT

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1. Introduction

Density Functional Theory (DFT) with the (semi-)local Density Functional Approximation (DFA) is an inexpensive computational method for a wide spectrum of electronic structure problems. However, the introduced approximations turn out to be too crude for certain problems. One of these is the description of localized states in extended systems where spurious electron self-interaction leads to an over-delocalization of electronic states. The evident symptom of this tendency is the wrong curvature of the energy for fractional electron systems. GGAs are $\delta$-convex thus they favor fractional, delocalized states [1,2]. This bias is especially apparent in the failure to predict relative stabilities of free and (self-)trapped charges [3].

An example process where charge trapping is of great technological importance is photo-catalysis on TiO$_2$ surfaces [4]. TiO$_2$ is utilized in processes such as water and air purification and is of potential use as a catalyst for solar into chemical energy conversion [4–6]. Oxidative power for those processes is delivered through trapped hole states generated in photoexcited TiO$_2$. Although a lot of research has been done, the exact nature of the hole traps in TiO$_2$ remains unclear. Measurements such as electron paramagnetic resonance [7,8], photoluminescence [9–11], transient absorption [12,13] spectroscopies or oxygen desorption [14] show that hole trapping sites in rutile and anatase TiO$_2$ are centered on oxygen atoms, and that both surface and lattice sites are present. However, the two phases differ in photo-catalytic activity and the precise reason for this is not clear [4]. Certainly, a different charge trapping capability of the two phases [15] is of vital importance here as the energetics of trapping sites in the bulk and in the surface layers will determine holes availability for the reaction and their oxidative power.

In this Letter, we consider hole trapping in the bulk of photoexcited TiO$_2$ by means of the $\Delta$-Self-Consistent Field (DFA) DFT [16]. We introduce a simple procedure which is parameter free and provides a systematic way to search for trapping sites in extended systems. To estimate relative stabilities of localized versus delocalized states we correct DFT energies for the biased description of charge localization processes. We associate this correction with the non-linearity of the energy for fractional excitations and apply the procedure to rutile and anatase TiO$_2$. We find that the electronic hole localizes on a lattice oxygen forming a small-polaron [17–19] trapping center in agreement with experimental measurements [20] and LDA+U calculations [21]. Our work provides relative stabilities of the delocalized and the localized hole states and compares them with photoluminescence data.

2. Computational details

We performed DFT calculations within the Projector-Augmented Wave formalism implemented in the GPAW code [22,23]. Pseudo wave-functions/densities and potentials were represented on an uniform, real-space grid with a spacing of 0.2 Å. To account for exchange–correlation effects we used the RPBE functional [24].

Excited-state (ES) energies were obtained with generalized $\Delta$-SCF [25,16]. Application of the more rigorous, but computationally much more demanding, ES methodologies is not feasible since the localized nature of the trapped hole state involves long-range atomic relaxations which can only be captured in large systems. The TiO$_2$ rutile (P4$_2$/mmm) and anatase (I4$_1$/amd) atomic structures were optimized, and the resulting cell parameters (rutile: $a = 4.691$, $c = 2.975$, $u = 0.3061$; anatase: $a = 3.829$, $c = 9.744$, $u = 0.3061$; rutile: $a = 4.691$, $c = 2.975$, $u = 0.3061$; anatase: $a = 3.829$, $c = 9.744$, $u = 0.3061$)
u = 0.2062) differed by less than 3% from the experimental ones [5,26]. We have studied a range of unit cell sizes defined by lattice vectors \( \mathbf{a} = m(\mathbf{a} + \mathbf{b}) \), \( \mathbf{b} = n(\mathbf{a} - \mathbf{b}) \), \( \mathbf{c} = \mathbf{c} \) for rutile; and \( \mathbf{a} = \mathbf{a}_0 \), \( \mathbf{b} = \mathbf{b}_0 \), \( \mathbf{c} = \mathbf{c}_0 \) for anatase, \( \mathbf{a}_0 \) and \( \mathbf{c}_0 \) being the vectors of the respective tetragonal crystallographic cells. For rutile \([m,n,o] = [3,2,2]\) and for anatase \([p,q,r] = [2,3,2]\) cells were found sufficient to describe localization phenomena, both containing 144 atoms. The Brillouin zone was sampled on \( 3 \times 2 \times 2 \) and \( 3 \times 2 \times 1 \) Monkhorst-Pack mesh for rutile and anatase, respectively.

3. Procedure

Application of (semi-)local DFA to polaronic systems is often troublesome. Classic example of their failure is hole localization around aluminum substitution in \( \alpha \)-quartz. GGA predict the hole to be delocalized over four oxygen atoms surrounding the defect [27] whereas experiments clearly indicate that the hole is mostly confined to one oxygen.

The problem of charge self-trapping is even more difficult as the delocalization error takes its maximum – we compare a completely delocalized state with a fully localized one. Therefore a simple use of (semi)-local DFA does not provide localized solution for the electronic hole in TiO\(_2\). Here we approach the problem by making an assumption on the nature of localized hole state and then we estimate its stability in a possibly unbiased way. The procedure consists of four steps: we (1) produce an initial hole orbital; (2) find a distorted association with the presence of a hole orbital in the Valence Band (VB); (3) construct the Potential Energy Surface (PES) along the distortion; (4) correct PES for the over-delocalization error.

3.1. Initial guess

A reasonable choice for a trial hole orbital can be derived from the Projected Density of States (PDOS) (Figure 1). Both in rutile and anatase the top of the VB is composed mostly form the oxygen’s \( p \) orbitals perpendicular to the flat OTi\(_3\) unit. Since \( p_z \) participates in \( \pi \) bonding which is considerably weaker than \( \sigma \) (Ti-O) it forms the top of the VB and offers less destabilization upon electron removal. Choice of a single \( p_z \) is also supported through a group theoretical reasoning: \( p_z \) is the only oxygen’s atomic orbital belonging to the \( b_1 \) irreducible representation of the local OTi\(_3\) symmetry point group – \( C_3v \). Since \( b_1 \) is largely non-bonding it is highest in energy. We construct the orbital by taking the difference between the true and the pseudo oxygen atomic \( p_z \) orbital inside an augmentation sphere of radius 1.4 Bohr, \( \phi_p (\mathbf{r}) = |\phi_p^0 (\mathbf{r} - \mathbf{R}^0) - \phi_p^0 (\mathbf{r} - \mathbf{R}^1)| \), where \( \mathbf{R}^0 \) is the position of the chosen oxygen atom and \( \phi_p^0 \), \( \phi_p^1 \) are pseudo partial wave and all-electron partial wave respectively, of the atom [16].

3.2. Finding distortion

To find the distortion associated with the presence of the localized hole orbital, \( \phi_h \), in the VB we excite an electron from its normalized expansion in \( M \) occupied states to the lowest conduction band. This is achieved by modifying the electron density at each self-consistency cycle,

\[
n(\mathbf{r}) = \sum_{i=1}^{M} |\psi_i(\mathbf{r})|^2 - \sum_{ij} c_{ij}^* \psi_i(\mathbf{r}) \psi_j(\mathbf{r}) + |\psi_{\text{M},1}(\mathbf{r})|^2.
\]

With such constraint density we now relax the atomic structure. Initially the expansion of the hole orbital, \( \phi_h (\mathbf{r}) \), in Bloch states is largely delocalized over all the equivalent oxygen atoms. However, as the self-consistency cycle and the structure relaxation proceed a single band-gap state localized on the chosen oxygen atom is formed. Hence a rather simple approximation, \( \phi_h (\mathbf{r}) \), leads to a state having \( \pi \) ionic character. The electron removal weakens the \( \pi \) (TiO) bond and results in its elongation. The direction of the distortion around the created localized hole is along the O\(_2\) breathing mode.

3.3. Constructing PES

Using linear interpolation between the equilibrium Ground State (GS) geometry and the distorted one we generate set of structures. Along this path we then calculate PES by removing an electron from the top of the Valence Band (VB) and placing it at the bottom of the Conduction Band (CB).

\[
n(\mathbf{r}) = \sum_{i=1}^{M-1} |\psi_i(\mathbf{r})|^2 + |\psi_{\text{M},1}(\mathbf{r})|^2.
\]

The frontier bands correspond to VB and CB maximum and minimum, respectively, as large unit cells are used and the band structure is multiply folded. The resulting PES are shown on Figure 2. Clearly, for a larger distortion the ES PES deviates from an ideal...
harmonic behavior of the GS PES and the presence of a localized and delocalized states can be distinguished. The hole self-traps on one sites and the degree of localization is monitored with the contribution of \( \phi_0(r) \) to the hole density. This contribution increases from \( \propto N^{-1} \), \( N \) being unit cell size, to about 0.75 (for all cell sizes used) as the structure distorts. The excited electron remains delocalized over all the titanium atoms thus it does not bias the localized or the delocalized nature of the hole through Coulombic interaction. We calculated a non-screened Coulomb interaction between the hole and the excited electron and found a difference of \( \approx 0.05 - 0.10 \) eV between the localized and the delocalized hole states. The inclusion of screening (optical dielectric constant \( \epsilon_{\infty} = 7 \) [28]) makes this effect negligible. A proper description of titanium \( d \) states might lead to electron self-trapping [29] but it is not an issue here.

### 3.4. Correcting PES

States along the calculated PES are characterized by different degree of localization. At the non-distorted structure the hole is delocalized over all the oxygen lattice sites, the degree of the hole localization is \( 1/N \) where \( N \) is the number of oxygen lattice sites. As we move along the distorting coordinate the hole localizes on one site therefore the degree of localization tends to 1. \( \delta N \)-convexity of (semi-) local DFA energetically favors charge delocalization therefore areas on PES due to more localized states are erroneously elevated. To correct for this inconsistent description we employ the fact that the exact DFT energy is linear with a change in the occupation of the Highest Occupied State (HOS) [30]. The more localized the HOS is the larger is its nonlinear deviation. If HOS is completely delocalized (delocalized limit) a straight line behavior is recovered, though with incorrect slope [2].

The ES energy is generally not linear in fractional excitation number. However, at low intensity excitation when one of the excited carries remains delocalized over large unit cell the electron–hole interaction is small and more importantly constant along the distortion. The latter is in analogy to the interaction of a charge with uniformly charged background. Therefore only a residual, fixed nonlinearly will be added to a larger effect due to charge localization.

Accordingly, by removing the non-linearity of ES energy at different distortion we achieve a more consistent description – we treat all the points along ES PES at delocalized limit. Assuming that the shape of GS PES is correct along the distortion the ES energy at delocalized limit equals

\[
E_{ES} = E_{ES} - E_{LC} = E_{GS} + \left. \frac{\partial E_{ES}(\lambda)}{\partial \lambda} \right|_{\lambda = 0} \lambda,
\]

where \( \lambda \) is fractional excitation number and \( E_{LC} \) is the sought correction to ES PES.

We calculate the correction to the ES PES at different distortion by constructing, \( E_{ES}(\lambda) \) and fitting to a parabola \( E_{ES}(\lambda) = a \lambda^2 + b \lambda + c \), where \( a \) is the sought correction, \( E_{LC} \) (Figure 3a).

### 4. Discussion

On Figure 3b the corrected PESs are presented. In rutile stabilities of the delocalized and the localized hole states are comparable, whereas in anatase the latter is favoured by 0.2 eV. Energetics of band gap states can be accessed with photoluminescence (PL) measurements. At low temperatures a PL peak of a vibronic transition is centered at the direct (Franck–Condon) transition from the minimum of the ES PES to the GS PES (see the inset in Figure 3b). Neglecting the difference between zero point energies of the GS and the ES the position of the PL peak is given by \( E_p = E_g - R - S \), where \( E_g \) is the band gap (3.0 eV and 3.2 eV [5] for rutile and anatase, respectively), \( R \) is the GS energy associated with the excited state PES displacement and \( S \) is the small-polaron stabilization. Accordingly, we locate PL peaks at 2.2 and 2.5 eV for anatase and rutile, respectively. The \( P \) value for anatase is smaller that for rutile, despite anatase larger band gap, \( E_g \). The reason for this is both stronger polaron binding and larger energy associated with the distortion, \( R \). The experimental value of the PL transition for anatase, measured picoseconds after excitation, amounts to 2.3 eV and is red-shifted by 0.2 eV within nanoseconds [11]. For rutile only nanosecond data is available and values in the range of 2.6–2.9 eV [9,10] are reported. Sub-nanosecond evolution of the photoluminescence [11], and also of the absorption [13] spectra, is possibly due to redistribution of holes between trapping sites both in the bulk and on the surface. The agreement between the experimental and the calculated values, and more importantly the prediction of a smaller \( P \) value for anatase despite a larger band gap, suggests that these transitions are due to the bulk hole small-polaron and the conduction band electron recombinations.

Based on Huang–Rhys model [31] for a single frequency, \( \omega_0 \), coupled vibronic transition we estimate the band's Full Width at Half Maximum. For Gaussian shaped peak \( FWHM = 2 \sqrt{2 \ln(2)} \hbar \omega_0 \), what gives 0.5 and 0.7 eV using \( \hbar \omega_0 \), values of the high frequency longitudinal optic mode of 0.10 eV [32] and 0.11 eV [33] for rutile and anatase, respectively. Calculated widths agree with the observed broadness of the PL peaks.

![Figure 3](image-url)
The positions of the valence band edges with respect to the vacuum level coincide in rutile and anatase TiO₂ [4]. This allows us to directly compare stabilities of the localized hole states in both phases. Clearly anatase offers stronger bulk trapping centers.

5. Conclusion

In conclusion, our simple procedure provides a systematic way to search for trapping sites in extended systems. Application of $\Delta$-SCF allows to probe a system with a desired density perturbation. To estimate stabilities of the found trapping sites we use a simple correction based on the non-linearity of the energy versus the fractional electron number. In this respect the procedure resembles DFT + $U$ which for a certain parameter $U$ removes the incorrect curvature of energy as a function of number of electrons [34]. However, DFT + $U$ also affects eigenvalues, here we only remove the biased description of localization process. Our procedure is simple and parameter free. By far the largest material-specific variable is a choice of an initial orbital. A more thorough discussion will be published in future.

Using the described methodology we have shown that the stability of the delocalized and the self-trapped polaron hole states in rutile TiO₂ bulk is comparable, whereas in anatase the trapped hole state is favoured by 0.2 eV. Our results are in good agreement with the published photoluminescence spectra and provide a compelling argument favouring small-polaron as the searched hole trapping center in TiO₂.

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Electronic hole transfer in rutile and anatase TiO$_2$: Effect of a delocalization error in the density functional theory on the charge transfer barrier height

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We analyze the deformation of the potential energy surface (PES) due to the incorrect description of fractional electron systems (the nonlinearity of the energy with electron number) within a (semi)local density functional theory (DFT). Particularly sensitive to this failure are polaronic systems where charge localization is strongly coupled to lattice distortion. As an example we calculate the adiabatic PES for the hole transfer process in rutile and anatase TiO$_2$. (Semi)local DFT leads to qualitatively wrong, barrierless curves. Removal of the nonlinearity improves the PES shape and allows us to calculate hole mobilities.

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Introduction. Inconsistent treatment of states with different degrees of localization is a known failure of standard (semi)local density functional theory (DFT). A clear case is the dissociation of X$_2$$^+$ systems, such as He$_2$$^+$$^1$, for which the solutions $X^\ast$$^1$$^X$$^1$$^2$ should be degenerated for $0 \leq \lambda \leq 1$ at infinite separation whereas (semi)local DFT favors energetically homolytic $X^\ast$$^2$$^X$$^0.5$$^X$$^0.5$ dissociation.$^1$ This bias can be traced back to the behavior of fractional electron systems. The exact energy is linear as the number of electrons is varied between integers.$^2$ (Semi)local approximations are $\delta N$ convex, thus solutions with electron density delocalized over several fragments are artificially favored over those having an electron localized on one fragment.$^3$$^4$ This biased behavior is related to the spurious electron self-interaction present in the common functionals. The relation, however, is by far not a straightforward one as it has been shown that even one-electron self-interaction free methods fail to reproduce linearity of the energy as a function of electron number.$^1$$^3$

The inconsistent description of states with different degrees of localization is especially troublesome in polaronic systems where the charge localization is coupled to lattice distortion.$^5$$^6$ (Semi)local DFT artificially elevates areas on the potential energy surface (PES) related to more localized states, therefore it provides too delocalized solutions and incorrect atomic structures. Such PES deformations lead to incorrect pictures of processes where the degree of localization changes. Charge transfer is one of these processes as states along a charge transferring coordinate vary in the amount of charge sharing between the transferring sites. Here we analyze the PES arising from the electronic hole transfer in a technologically important photocatalyst—titanium dioxide. Transport of photogenerated holes to surfaces is a necessary step preceding photocatalytic reaction. In this material hole transfer largely determines photocatalytic efficiency as charge recombination in the bulk and reactions on the surface occur on similar time scales.$^7$ Various experimental techniques such as electron paramagnetic resonance,$^8$$^9$ transient absorption spectroscopy,$^{10}$$^{11}$ and photoluminescence$^{17}$$^{19}$ have revealed that photogenerated holes are trapped. Yet the nature of the trapping sites has remained obscure. Only recently it is becoming evident that holes self-trap intrinsically, both in rutile,$^8$$^9$ and in anatase,$^{20}$ forming O$^-$ small polarons.$^{21}$

Model. To examine the effect of the $\delta N$ convexity of (semi)local functionals on the PES for the self-trapped hole transfer, we first introduce a two-site model of the process. The hole is transferred between lattice sites $L$ and $R$: $L^\ast$$^X$$^0$$^+$$^R$$^X$$^0$$^+$$\rightarrow$$^L$$^X$$^0$$^+$$^R$$^X$$^0$$^+$, where the hole number can be fractional, $\lambda \in [0,1]$. We assume that the system interacts with the lattice via a single mode $x$ and at $\lambda = 0$ the PES is harmonic, $E(x,\lambda = 0) = \frac{1}{2}Kx^2$. In the basis of orthonormal states localized on these sites, the electronic Hamiltonian takes the form

$$H_x = \begin{pmatrix} \varepsilon_L + V_x & t \\ t & \varepsilon_R - V_x \end{pmatrix}$$

(1)

$\varepsilon_L,\varepsilon_R$ are the on-site energies associated with the basis functions $[L]$ and $[R]$; $t$ is the electronic coupling between the sites; and $V$ is the strength of the electron-mode interaction.

In the static approximation—including the mode kinetic energy—the hole transfer occurs on a single PES. We construct the PES by removing a fraction $\lambda$ of a hole from the highest occupied eigenstate $\varepsilon$ of $H_x$:

$$\Delta E(x,\lambda) = \frac{1}{2}Kx^2 - \lambda \varepsilon(x).$$

(2)

For $L$ and $R$ representing O$^2$$^-$ lattice ions, $\varepsilon$ is the antibonding solution of $H_x$:

$$\varepsilon(x) = [\varepsilon_L + \varepsilon_R + 4\sqrt{\tan[2\xi(x)]^{-2} + 1}] / 2,$$

(3)

where $2\xi(x) = \arctan([2t/(\varepsilon_L - \varepsilon_R + 2Vx)])$. In the following we consider $x \leq 0$; for $x > 0$ indexes $L$ and $R$ should be interchanged.

The hole then occupies the antibonding state $|\Psi\rangle = |L\rangle \cos[\xi(x)] + |R\rangle \sin[\xi(x)]$. If $\xi(x) = 0$, the hole is confined to the $L$ site; if $\xi(x) = \pi/4$, the hole is equally shared between the two sites—therefore $\xi(x)$ defines the degree of hole localization. In the absence of electron-mode coupling, $\xi$ is independent of the coordinate $x$. The composition of eigenstates then does not change along the coordinate; the PES should not be deformed if there is any bias toward a more localized or delocalized state. Contrary, for a nonzero $V$ the states along $x$ differ in the degree of localization and their inconsistent treatment will result in a deformed PES.

A $\delta N$ convexity of a (semi)local DFT leads to such inconsistent descriptions. For a quadratic behavior of the total energies of subsystems $L$ and $R$, the on-site energies vary linearly with their occupations: $\varepsilon'(\xi) = \varepsilon - \alpha \lambda \cos^2(\xi)$ and

$$\delta N = \frac{\partial^2 E}{\partial \lambda^2} = \frac{\varepsilon'(\xi)}{\varepsilon(\xi)} = \frac{\alpha \lambda}{\varepsilon(\xi)}$$

(4)

with $\alpha = t^2/\varepsilon$. One can see that $\delta N$ is convex if the on-site energies of subsystems are too delocalized, or $\delta N$ is concave if the on-site energies are too localized.
FIG. 1. (Color online) Top: The PESs for a two-state model of a hole transfer between equivalent fragments (full lines) and the deformed PESs due to $δN$ convexity of the energy (dashed lines). Bottom: The hole localization on the $L$ site. Curves are plotted for $t = 0.2$ eV (black) and $t = 0.02$ eV (yellow/gray) with $V = 1.7$, $K = 3.5$ eV corresponding to the path $E$ in rutile [see Fig. 2 b]. Zero energy is at the minimum of the nondeformed PES and the deformed PES is aligned at $E → ∞$.

$ε_ρ(ζ) = ε_ρ - αλ sin^2(ζ)$, $α > 0$. In Fig. 1 we show the effect of such a quadratic deviation on the PES when sites $L$ and $R$ are equivalent. For $α = 1$ the PES shape is deformed around the transition point. The deformation increases with stronger electronic coupling $t$ as the variation of the degree of localization extends toward larger $|x|$.

A non-self-consistent (preserving the site occupations) first-order expansion in $\alpha$ of the deformed PES yields

$$ΔE(x, λ) ≈ ΔE(x, λ) + αλ^2 f(ζ(x)),$$

where $f(ζ) = \frac{1}{2} + \frac{1}{2}[2cos^2(ζ) - 1]/\sqrt{tan(2ζ)^2 + 1}/2$. The correction to the PES of the system with a single hole is then $αf(x)$ and can be calculated as a quadratic nonlinearity of $ΔE(x, λ)$. As one could expect, the correction is twice as large for the localized hole, $f(ζ = 0) = 1$, compared to the hole shared between two sites, $f(ζ → π/4) = \frac{1}{2}$.

Computational details. We perform revised Perdew-Burke-Ernzerhof (RPBE) DFT calculations within the projector augmented-wave formalism implemented in the GPAW code. The wave functions, densities and potentials are described on a grid with a spacing of 0.2 Å. Atomic structures are defined by lattice vectors $a^i = 3(a + b)$, $b^i = 2(a - b)$, $c^i = 2c$ for rutile, and $a^i = 3a$, $b^i = 3b$, $c^i = 2c$ for anatase, $a$, $b$, and $c$ being the vectors of the respective tetragonal crystallographic cells. The Brillouin zone is sampled on $3 × 2 × 2$ and $2 × 2 × 1$ Monkhorst-Pack meshes for rutile and anatase, respectively.

The basic, oxygen-based, building motif of the anatase and rutile structures is a flat $C_{2,2}$-symmetric OTi$_3$ unit. Upon hole localization the three OTi bonds elongate by 0.1–0.2 Å, preserving the initial symmetry. The hole occupies a $p$-like orbital centered on the oxygen site and is perpendicular to the OTi$_3$ plane. In anatase such distortion renders the localized hole state more stable than the delocalized one, whereas in rutile the two have a comparable stability.

Consider hole transfer between two neighboring oxygen sites $L$ and $R$. There are several such possible pairs of oxygen atoms (see Fig. 2). For each pair we construct a set of structures $Q$ defined through linear interpolation between the distortions localized on the two sites $Q_L$ and $Q_R$, respectively:

$$Q = [x(Q_R - Q_L) + Q_L + Q_R]/2.\

For the constructed paths, we then calculate a set of PESs, $ΔE′(x, λ)$, by removing a fraction of an electron $λ$ from the highest occupied state and placing it at the bottom of the conduction band using linear expansion $Δ-SCF$ (delta self-consistent field). To correct the PESs for the spurious delocalization error, we remove the PES quadratic nonlinearity in $λ$:

$$ΔE(x, λ = 1) = ΔE′(x, λ = 1) - αf(x).\

Results and discussion. In the top plots of Fig. 3 we show PESs resulting from RPBE DFT calculations for different paths. The curves are seen to exhibit a drop around the transition point. We have shown that this characteristic kink is caused by the $δN$ convexity of (semi)local functionals. At $x = 0$ the delocalization of the hole charge is the largest—the hole is shared between two sites; therefore the relative error with respect to the localized state takes its maximum. The quadratic nonlinearity of $ΔE′(x, λ)$, $αf(x)$, is shown in the middle plots of Fig. 3. The two-state model predicts that at large $|x|$ the correction should be twice as big as at $x = 0$. This ratio is not strictly conserved for some paths. The hole orbital

FIG. 2. (Color online) Hole transfer paths between neighboring oxygen lattice sites in TiO$_2$.

FIG. 3. (Color online) Top: PESs $ΔE(x, λ = 1)$ resulting from RPBE DFT calculations are plotted for different hole transfer paths. Middle: The nonlinearity of PES $αf(x)$ with respect to hole number $λ$. Bottom: The corrected PES, $ΔE(x, λ = 1) = ΔE′(x, λ = 1) - αf(x)$.\n
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hybridizes with the surrounding orbitals, therefore the degree of localization can to some extent be different than in the model. In the bottom plots of Fig. 3 we show the corrected PESs, $\Delta E(x, \lambda = 1)$. Their shape is improved, notably the kinks around $x = 0$ are removed.

We use the thus corrected PESs to calculate high-temperature hole mobility. At high $T$ small-polaron transport is dominated by the hopping mechanism. If the relative dynamics of the hole is fast compared to lattice fluctuations, the hole instantaneously follows the lattice coordinate and the charge transfer proceeds via barrier crossing at the transition point—the adiabatic limit. The hopping frequency in this case is given by

$$ k = \frac{\Omega}{(2\pi)} \exp \left[ -\frac{E_{b}^\text{ad}}{(k_B T)} \right], \quad (5) $$

where $E_{b}^\text{ad}$ is the adiabatic barrier height and $\Omega$ is the transferring mode frequency. In the nonadiabatic regime the hole is not able to follow the distortion. The transfer between two sites occurs at the intersection of two nonadiabatic PESs with a certain transition probability. The resulting hopping frequency in this case is given by

$$ k = \pi \sqrt{\frac{4\hbar^2 E_{b}^\text{nad} k_B T}{E}} \exp \left[ -\frac{E_{b}^\text{nad}}{(k_B T)} \right], \quad (6) $$

where $E_{b}^\text{nad} = E_{b}^\text{ad} + t$ is the nonadiabatic barrier height and $t$ is the electronic coupling. We discriminate between these cases by calculating the parameter $\eta = t^2/(\hbar\Omega\sqrt{E_{b}^\text{nad}k_B T})$ describing the relative inertia of the nuclear and electronic motion. \cite{27} For $\eta > 1$ we assume adiabatic transport and otherwise the nonadiabatic one. At 1300 K we find all the nearest paths in rutile and paths $A$ and $B$ in anatase adiabatic. Apart from paths $C$ and $E$ in rutile, this is in accordance with wave-function calculations \cite{28} (our notation $ABC \ldots$ corresponds to $DFBCEA$ and $BCADE$ in Ref. 28 for anatase and rutile, respectively).

We calculate the drift mobility using the Einstein-Smoluchowski relation $\mu = eD/(k_B T)$. $D$ is the average hole diffusion coefficient $D = \sum_{i \in \text{eq}} n_i k_i |R_i|^2/3$, where $n_i$ is a number of equivalent paths, $k_i$ is the transfer frequency, and $|R_i|$ is the transfer distance. The two-site model for small-polaron hopping holds if $\eta_1 = t/E_{b}^\text{nad} \ll 1$.\cite{27} For anatase we find $\eta_1 \in (0.05, 0.56)$ eV and for rutile $\eta_1 \in (0.27, 0.67)$ eV. Smaller $\eta_1$ in anatase indicates that the hole in this phase is more localized. (For what is also reflected in larger nonlinearities $\alpha_f$, see the middle plots in Fig. 3.)

The characteristic parameters of the different hole transfer paths in anatase and rutile are shown in the Supplemental Material.\cite{28} We only note here that $\hbar\Omega \approx 20$ meV in rutile and $\approx 40$ meV in anatase is much lower than the highest-frequency mode at $\approx 100$ meV used to calculate hole mobility in Ref. 28. We find our values in accordance with the fact that the transfer coordinate arises mostly from the displacements of the cationic sublattice corresponding to the breathing mode of the flat OTI$_3$ unit. Such vibrations resemble the optical modes $B_{1u}$ at 50 meV and 64 meV in anatase \cite{30} and $B_{1u}$ at 14 meV and 50 meV in rutile.\cite{31}

In units of cm$^2$ V$^{-1}$ s$^{-1}$, mobilities measured in electrical conductivity experiments at 1300 K are 0.25 (Ref. 32) for single crystal and 0.16, 32 $5.0 \times 10^{-2}$ (Ref. 33) for polycrystalline samples. At this temperature we find hole mobilities of $5.2 \times 10^{-2}$ and $4.0 \times 10^{-2}$ for anatase and rutile, respectively. At 873 K the transient grating technique predicts a value of 0.18,\cite{34} whereas we find $3.3 \times 10^{-2}$ for anatase and $3.1 \times 10^{-2}$ for rutile.

Clearly, the calculated values underestimate the hole mobility. A better guess for the transition points (achieved by constraining the hole to be equally shared between the hole transferring sites) lowers the adiabatic barriers from $E_{b}^\text{ad} \in (0.14, 0.39)$ to $E_{b}^\text{ad} \in (0.09, 0.39)$ eV in anatase and from $E_{b}^\text{ad} \in (0.14, 0.29)$ to $E_{b}^\text{ad} \in (0.06, 0.21)$ eV in rutile, whereas only barrierless paths could provide mobilities close to the experimental ones.

This underestimation is likely due to the contribution of valence-band (VB) holes to the hole conduction mechanism. At 1300 K—assuming hole stabilization of 0.05 eV in rutile and 0.2 eV in anatase—\cite{29} ∼39% and ∼14% of the total hole concentration occupies the VB in rutile and anatase, respectively. Two types of hole transport mechanisms are more evident at lower temperatures, where the disparity between the band and small-polaron mobilities increases (the latter becomes relatively immobile). Room-temperature experiments indicate the existence of two hole dynamics time scales: a fast one, after excitation—hole transfer to the surface within $t \approx r^2D/(kT)$, where $r$ is the particle diameter and $D$ corresponds to the VB hole diffusion coefficient; and a much slower, nanosecond-microsecond decay of surface trapped holes.\cite{19,11,12,13,14,15,16} We think that these two time scales are related to the VB band and the small-polaron transport mechanisms.

**Conclusion.** In summary, we have shown that the spurious nonlinearity of the total energy in a (semilocal) DFT leads to a significant deformation of the PES if the states on the PES differ in the degree of charge localization. As an example we studied the electronic hole hopping in TiO$_2$. (Semilocal) DFT results in a quantitatively incorrect barrierless PES. By removing the energy nonlinearity in the fractional hole number from the PES, we improved the PES shape. With the thus corrected PES we calculated high-temperature hole hopping mobilities. Our results indicate that both the trapped and the VB holes contribute to the hole transport mechanism.

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The effective force constant $K$ is calculated from $E(x, \lambda = 0) = Kx^2/2$. Then by fitting $E(x, \lambda = 1) - E(x, \lambda = 0)$ to the antibonding eigenstate of the model Hamiltonian we obtain $t$ and $V$.

From these we determine: The effective mode frequencies

$$\Omega = K^{1/2}/|(Q_R - Q_L)M^{1/2}|,$$

where $M$ is a diagonal matrix of atomic masses; The non-adiabatic barriers

$$E_b^{\text{nad}} = V^2/2K + Kt^2/2V^2;$$

The adiabatic barriers

$$E_b^{\text{ad}} = E_b^{\text{nad}} - t.$$

### TABLE I: Characteristic parameters for the different hole transfer paths.

| R | $|R|$ | $\hbar\Omega$ | $E_b^{\text{nad}}$ | $E_b^{\text{ad}}$ | $t$ | $T_c = 1300K$ | $T_c = 1200K$ |
|---|---|---|---|---|---|---|---|
| A | 2 | 2.48 | 0.38 | 0.19 | 0.15 | 0.44 | 3.00 | 1.7 $10^{12}$ |
| B | 4 | 2.84 | 0.37 | 0.14 | 0.18 | 0.56 | 4.43 | 2.7 $10^{12}$ |
| C | 4 | 3.10 | 0.38 | 0.29 | 0.06 | 0.17 | 0.45 | 9.9 $10^{11}$ |
| D | 2 | 3.83 | 0.39 | 0.30 | 0.03 | 0.09 | 0.12 | 3.4 $10^{11}$ |
| E | 2 | 3.83 | 0.42 | 0.30 | 0.05 | 0.14 | 0.27 | 6.7 $10^{11}$ |
| F | 1 | 4.02 | 0.44 | 0.39 | 0.02 | 0.05 | 0.05 | 7.2 $10^{10}$ |

Anatase

| R | $|R|$ | $\hbar\Omega$ | $E_b^{\text{nad}}$ | $E_b^{\text{ad}}$ | $t$ | $T_c = 1300K$ | $T_c = 1200K$ |
|---|---|---|---|---|---|---|---|
| A | 1 | 2.57 | 0.41 | 0.15 | 0.26 | 0.64 | 17.00 | 1.3 $10^{12}$ |
| B | 8 | 2.83 | 0.42 | 0.14 | 0.28 | 0.67 | 15.99 | 1.6 $10^{12}$ |
| C | 2 | 2.98 | 0.40 | 0.23 | 0.17 | 0.42 | 8.60 | 4.6 $10^{11}$ |
| D | 1 | 3.93 | 0.40 | 0.29 | 0.10 | 0.27 | 3.13 | 3.1 $10^{11}$ |
| E | 1 | 4.06 | 0.45 | 0.25 | 0.20 | 0.45 | 7.60 | 6.3 $10^{11}$ |

Rutile
Paper III

Zawadzki P., Rossmeisl J., Jacobsen K. W.; Polaronic defect states from (semi)local DFT. Application of Δ-SCF DFT to optical absorption of the $V^-$ center in MgO. (manuscript)
Polaronic defect states from (semi)local DFT.
Application of $\Delta$-SCF DFT to optical absorption of the $V^-$ center in MgO.

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Abstract
By means of the linear expansion $\Delta$-self consistent field density functional theory ($\Delta$ SCF DFT) we calculate defect states and optical absorption spectra of the charged Mg vacancy in MgO ($V^-$ center). The states are localized on $M \in \{1, 2, 4, 6\}$ oxygen sites surrounding the vacancy. (Semi)-local provides the defect state energies that are burden with relative error proportional to $1/M$. Removal of this error necessary to obtain qualitatively good defect optical absorption spectra. Furthermore such correction reduces the dependence of DFT+$U$ results on the choice of parameter $U$.

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The small polaron concept—an electron-polarisation field quasiparticles with size comparable lattice spacing[1, 2]—has been extensively used to describe charge carriers in materials ranging from DNA[3, 4] and proteins[5], organic semiconductors for optoelectronic devises and solar cells[6], to inorganic materials such as LiFePO₄ for batteries[7], HfO₂ high-k dielectric oxide for metal-oxide-semiconductor field-effect transistors [8] and Fe₂O₃ [9, 10] or TiO₂[11] for photocatalysis, etc. Since the charge transport phenomena is strongly affected by small-polaron formation and it is an essential steps in many applications, a through understanding of polaronic effects is important to elucidate materials limitations and opportunities.

First principles calculations can provide an important insight into the nature of charge carries. The density functional theory (DFT) is most commonly used method as studies of polaronic systems often require simulation cells with ~100 atoms—a size that is currently intractable by accurate wave function techniques. Applications of state of the art DFT approximations to small-polarons, however, often leads to qualitatively incorrect predictions[12–16] as the technique provides biased treatment of states with different degrees of localization [11, 17, 18]. Here we analyze the incorrect treatment of the polaronic defect states of the V⁻ center in MgO. The states are localized on \( M \in \{1, 2, 4, 6\} \) oxygen orbitals. Approximate DFT provides defect state energies that are burden with relative error inversely proportional to \( M \). Removal of this inconsistency is necessary for qualitatively correct descriptions of polaronic systems. We further calculate defect optical absorption spectra by means of the linear expansion \( \Delta \)-SCF DFT[19, 20]. This simple extension of the convectional DFT is particularly useful to polaronic systems as it allows to form localized charge states and calculate such key parameters as electron couplings.

A V⁻ center in MgO is formed upon neutron or gamma irradiation[21, 22]. The defect contains a single hole localized on an oxygen \( p \)-like orbital pointing towards the vacancy and the \( O_h \) symmetry of the Mg lattice site is lowered to the \( C_{4v} \)[23]. The electronic structure of the center is most easily understood within symmetry adapted linear combinations (SALCs) of orbitals. At the \( O_h \) symmetry the six oxygen orbitals directed towards the vacancy (see
Fig. 1) span $A_{1g}$, $T_{1u}$ and $E_g$ irreducible representations with basis functions:

\[
A_{1g} = (|\gamma_0\rangle + |\gamma_1\rangle + |\gamma_2\rangle + |\gamma_3\rangle + |\gamma_4\rangle + |\gamma_5\rangle)/\sqrt{6} \\
T_{1u}^1 = (|\gamma_0\rangle - |\gamma_5\rangle)/\sqrt{2} \\
T_{1u}^2 = (|\gamma_4\rangle - |\gamma_3\rangle)/\sqrt{2} \\
T_{1u}^3 = (|\gamma_2\rangle - |\gamma_4\rangle)/\sqrt{2} \\
E_g^1 = (|\gamma_1\rangle - |\gamma_2\rangle + |\gamma_3\rangle - |\gamma_4\rangle)/\sqrt{4} \\
E_g^2 = (2|\gamma_0\rangle - |\gamma_1\rangle - |\gamma_2\rangle - |\gamma_3\rangle - |\gamma_4\rangle + 2|\gamma_5\rangle)/\sqrt{12}
\]

The electronic coupling $J$ between equatorial pairs of orbitals is 0.19 eV and is negligible for axial ones[23]. Therefore the states $A_{1g}$, $T_{1u}$ and $E_g$ have relative stabilisations of $4J$ (bonding), $0J$ (non-bonding) and $-2J$ (anti-bonding), respectively.

An electron hole present in $E_g$ couples to $T_{1u}$ asymmetric mode lowering the symmetry to $C_{4v}$. SALCs then take the forms:

\[
A_1^1 = |\gamma_0\rangle \\
A_2^1 = (|\gamma_1\rangle + |\gamma_2\rangle + |\gamma_3\rangle + |\gamma_4\rangle)/\sqrt{4} \\
A_3^1 = |\gamma_5\rangle \\
B_2 = (|\gamma_4\rangle - |\gamma_3\rangle + |\gamma_2\rangle - |\gamma_1\rangle)/\sqrt{4} \\
E_1^1 = (|\gamma_1\rangle - |\gamma_3\rangle)/\sqrt{2} \\
E_2^1 = (|\gamma_2\rangle - |\gamma_4\rangle)/\sqrt{2}
\]

and the hole occupies a single $p$-like orbital, say $\gamma_0$ of $A_1^1$ state, surrounded by the deformed lattice—a bound small $O^{-}$ polaron is formed.

FIG. 1: A $V^{-}$ center in MgO lattice; oxygen (gray), Mg (black). A single electron hole localized on the oxygen $p$-like orbital on site 0 induces $O_h \rightarrow C_{4v}$ distortion along 0–5 axis. The isosurface shows the electron density difference between the $V^{-}$ with the hole constrained to the $A_1^1$ state and the $V^{2-}$ charge states at 0.03 e/Å$^{-3}$; yellow and blue are hole and electron densities, respectively. The figure was drawn using VESTA [24].
To calculate the PESs for the SALCs we perform DFT calculations within the Projector Augmented Wave formalism implemented in the GPAW code[25]. Wave-functions, densities and potentials are described on a real space grid with a spacing ≈ 0.2 Å. The MgO cubic unit cell is optimized and the resulting lattice constant is 4.267 Å (the experimental value is 4.212 Å). For the defect center we use a 215 atom 3x3x3 supercell for which we sample the Brillouin zone with a 2x2x2 Monkhorst-Pack mesh.

We construct SALCs by means of the linear expansion ∆-SCF[19, 20]. The method allows to subtract the electron density of the SALC expanded in KS states at each SCF cycle. The SALCs are formed from $p$-like orbitals defined as a difference between the true and the pseudo oxygen 1$p$ orbital of the PAW formalism[11, 17, 19]. These are zero outside the sphere of radius 0.74 Å. The expansion, however, is determined by the symmetry and the nodal structure of the composite orbitals rather than their exact extent. Moreover, since the SALCs form the basis for irreducible representations of the symmetry point group of the supercell, the expansions are largely formed by a single KS state of the appropriate symmetry and the nodal structure.

We construct the PESs along the $O_h \rightarrow C_{4v}$ distortion. Since the distortion is not spontaneous in (semi)local DFT we determine it by relaxing the system with an electron hole constraint to the $A_{1g}$ state. The structure minimizing Hellmann-Feynman forces corresponds to the minimum energy on the $A_{1g}$ PES (see arrows tangent to the $A_{1g}$ PES in Fig.1).

In Fig.2 we plot the non-adiabatic PESs along the $O_h \rightarrow C_{4v}$ distortion. The upper part shows results of PBE exchange-correlation (XC) [26] DFT calculations. Clearly, this (semi)local XC functional fails to predict the spontaneous distortion. The ground state is the $E_g$ at the $O_h$ symmetry instead of the $A_{1g}$ at $C_{4v}$. Furthermore the separation between the $O_h$ states is rather different from the expected $4J$, 0, $-2J$. The $T_{1u}$ almost coincides with the $A_{1g}$ whereas it should be $4J = 0.76$ eV up in energy.

Apart from these system specific inaccuracies there is an elemental error. Upon symmetry lowering the $A_{1g}$ and $A_{3u}$ states split from the $O_h$ state therefore their origin must be contained between $O_h$ states. Precisely, their energies at $\rho = 0$ should be $0J$ which is also the energy of the $T_{1u}$ state. The origin of the $A_{1g}$ and $A_{3u}$, however, lays well above the $O_h$ states—1.1 eV above the $T_{1u}$ state.

This shift arises because of the biased treatment of states with a different degree of localization—both the $A_{1g}$ and $A_{3u}$ are localized on a single $p$-like orbital whereas states
FIG. 2: The non-adiabatic potential energy surfaces (PESs) for the different symmetry states of the $V^-$ center along the $O_h(\rho = 0) \rightarrow C_{4v}$ distortion. Top: PBE PESs not corrected for the delocalization error; Bottom: PESs corrected by removal of the energy nonlinearity $\alpha f$. Full lines denote states involved in optical transitions of the center; arrows tangent to the $A_1^1$ are proportional to sum over Hellman-Feynman forces.

at $O_h$ symmetry are composed of 6 ($A_{1g}$), 4 ($T_{1u}$) and 2 ($E_g$) orbitals. Due to the non-linearly of the total energy (semi)local DFT favours more delocalized states [11, 18, 27, 28]. If $\alpha$ is the quadratic energy nonlinearity of a single orbital $|\gamma_i\rangle$ then for a composite system $|\Gamma\rangle = \sum_i^M c_i |\gamma_i\rangle$ the energy nonlinearity is $\alpha f = \alpha \sum_i^M |c_i|^4$, where $f$ is the degree of the electron localization in $|\Gamma\rangle$. For equal weights $|c_i| = 1/\sqrt{M}$ the relative error is inversely proportional to the number of orbitals contributing to the state: $f = 1/M$.

On Fig.3 we plot the energy nonlinearity for $O_h$ and $C_{4v}$ states. The relative error follows a $1/M$ trend and is constant along the $O_h \rightarrow C_{4v}$ distortion (see the inset plot in Fig.3) indicating that the states do not change along the distortion. The exception here is the $A_1^1$ state. This state is coupled to the distortion and the atomic surrounding of a single $\gamma_0$ orbital relaxes outward along the distortion. Therefore the spacial extent of this orbital becomes larger (more delocalized) hence its energy nonlinearity decreases as observed.

We remove the bias of the PESs description by subtracting the energy nonlinearity $\alpha f$. The bottom part of Fig.2 shows the corrected results. Firstly, the distortion is now spontaneous and rightly the $A_1^1$ is the ground state. The separation between the $O_h$ states also improves, specifically the $A_{1g}$ is 0.63 eV above the $T_{1u}$. Finally the correction recovers the correct
FIG. 3: The energy nonlinearity $\alpha_f$ follows $f = 1/M$ trend; $f$ is the degree of state localization, e.g. $f = 1/2$ for the $T_{1u}$ as this state is localized over two orbitals. The inset plot shows the energy nonlinearity along the $O_h(\rho = 0) \rightarrow C_{4v}$ distortion.

splitting of the $A_1^1$ and $A_1^3$ states from the $O_h$ states. $A_1^1$ and $A_1^3$ now originate at the $T_{1u}$ state.

To further check the quality of the corrected PESs we calculate the defect absorption spectra. The experimental absorption band consists of a broad peak centered at around 2.3 eV. The low energy part of the spectra is due to $A_1^1 \rightarrow A_1^2$ and $A_1^1 \rightarrow E$ transitions; absorption at higher energies involve $\pi$ states of the center[23, 29, 30]. In an electric field $V^-$ centers align and absorption of light polarized parallel to the direction of the applied electric field peaks at 1.85 eV ($A_1^1 \rightarrow A_1^2$); band due to perpendicular light polarization is located at 2.30 eV ($A_1^1 \rightarrow E$)[23, 29, 30].

Assuming single effective mode model in reduced coordinates $\rho = (m\Omega/\hbar)^{1/2} q$: The initial state $I = A_1^1$ is described by a displaced harmonic oscillator $E_I(\rho) = \frac{1}{2} \hbar \Omega (\rho - s)^2$ where $s = 6.9$ is the equilibrium lattice distortion; $\Omega$ is the effective mode angular frequency (calculated $\hbar \Omega$ is 0.065 eV and agrees with Ref.[23]). The final states $F \in \{A_1^2, A_1^3, B_2, E\}$ are not coupled to the coordinate and are given by $E_F(\rho) = \frac{1}{2} \hbar \Omega \rho^2 + \Delta_{IF}$ where $\Delta_{IF}$ describes their relative shift with respect to $A_1^1$ (for values of $\Delta$ see Supplemental Material). The absorption cross-section per defect $\sigma(\omega)$ due to vertical transitions from vibrational states located on the $E_I$ to states on the $E_F$ is proportional to the shape function $G_{IF}(\omega)$ and the oscillator strength $\tilde{f}_{IF}$. For large deformation $s \gg 1$ the $E_F$ can be treated
FIG. 4: Top: the optical absorption of the $V^-$ center. Bottom: the dichroism curve. PBE results (dashed lines) fail to reproduce the experimental data [29] (dotted lines) predicting absorption peak at too low energies and providing incorrect sign of the dichroic effect. Subtraction of the energy nonlinearity $\alpha f$ leads to a semi-quantitative agreement (full lines).

classically and $G_{IF}$ is a Gaussian centered at $\hbar \omega_{IF} = \hbar \Omega s^2 + \Delta_{IF}$:

$$G_{IF}(\omega) = \left[ w(T)/\pi \right]^{1/2} \exp \left[ (\hbar \omega - \hbar \omega_{IF})^2 w(T) \right]^{1/2}$$

with $w(T) = \tanh(h\Omega/2kT)/(sh\Omega)^2$ [23, 31]. To calculate oscillator strength $\tilde{f}_{IF} = (2m_e\omega_{IF}/e^2\hbar)\tilde{\mu}_{IF}^2$ we use approximate electronic transition moment $\tilde{\mu}_{IF} \approx (e/\sqrt{M_F}\hbar\omega_{IF})\sum_{n \in F} J_{0n}\tilde{d}_{0n}$ [30] where $\tilde{d}_{0n}$ and $J_{0n}$ are the vector connecting lattice site 0 and $n$ and the electronic coupling between $|\gamma_0\rangle$ and $|\gamma_n\rangle$, respectively; $1/\sqrt{M_F}$ is the normalization factor of the final state $F$. We calculate $J_{0n}$ as a one half of the energy difference between systems with hole constraint to the antibonding and the bonding combinations of the two orbitals: $((|\gamma_0\rangle \pm |\gamma_n\rangle)/\sqrt{2})$. For axial pairs we find 0.01 eV whereas for equatorial 0.19 eV. These values agree with Ref[23]. (For the calculated oscillator strength see Supplemental Material.)

In Fig. 4 we show calculated absorption bands. Transitions based on the corrected PES (PBE-$\alpha f$) reproduce the low energy part of the experimental spectra and lead to the zero dichroism point at 1.75 eV compared to experimental value of 1.85 eV [29]. The not-corrected absorption band is off by $\approx 1.0$ eV. Furthermore, semi-local DFT locates the $A_1^1 \rightarrow A_1^2$ at higher energy than the $A_1^1 \rightarrow E$ therefore predicts incorrect sign of the dichroic effect.

An extension of DFT that is often used to localize electrons or holes is DFT+$U$ [32, 33].
Using rotationally invariant formulation of the method [33] we have calculated optical transitions energies for different parameters $U$—dashed lines on Fig. 5. Clearly, DFT+$U$ results are strongly depended on choice of the parameter $U$. A simple removal of the total energy non-linearity (full lines), however, reduces this dependence. Moreover, for all $U$ such a posteriori correction preserves the energy difference between $A_1^1 \rightarrow A_1^2$ and $A_1^1 \rightarrow E$ transitions. This energy difference equals to $J$ and is directly related to the degree of the states localization. Thus for $U \in [0, 8]$ eV the correction removes the energetic bias in description of states with a different degree of localization.

In conclusion, we have studied the defect states of the $V^-$ center in MgO—an example where a single hole can localized on $M \in \{1, 2, 4, 6\}$ oxygen lattice sites. We have shown that the violation of the linearity of the total energy introduces relative errors that are inversely proportional $M$. Removal of this error is necessary for a quantitatively good description of the defect states PESs. We have further calculated the optical absorption spectra of the $V^-$ center by means of the linear expansion $\Delta$-SCF. The technique is particularly useful for studies of polaronic systems as it allows to form localized charge states and to obtain such key parameters as electron couplings.

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Supplemental Material

TABLE I: Parameters for the calculation of the optical absorption from the initial state $I = A_1^1$ to the final states $F$. $\Delta_{IF}$ is the vertical shift the $F$ PES with respect to the $A_1^1$ PES; $\hbar \omega_{IF}$ is vertical transition energy. Superscripts denote PBE and PBE corrected for the delocalization error results (PBE $- \alpha f$). $f_{IF}$ is the oscillator strength for light polarized $\parallel$ or $\perp$ to the distortion axis.

<table>
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<th>$F$</th>
<th>$\Delta_{IF}^{\text{PBE}}$</th>
<th>$\Delta_{IF}^{\text{PBE}$-$\alpha f}$</th>
<th>$\hbar \omega_{IF}^{\text{PBE}}$</th>
<th>$\hbar \omega_{IF}^{\text{PBE}$-$\alpha f}$</th>
<th>$f_{IF}^{\parallel}$</th>
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<td>0.69</td>
<td>1.76</td>
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Zawadzki P., Jacobsen K. W., Dahl S., Rossmeisl J.; Explaining oxidative trends of TiO$_2$—Hole trapping at anatase and rutile surfaces. (manuscript)
Explaining oxidative trends of TiO$_2$—Hole trapping at anatase and rutile surfaces.

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Abstract

Photo-catalysis is presently used in a large variety of applications such as water and air purification, self-cleansing surfaces, anti-fogging coatings. Furthermore, for future sustainable fuel production from solar light efficient photo-catalysis is crucial. A successful photo-catalytic transformation of absorbed photon energy must comprise: separation of photo-generated electron-hole pairs, carrier transport to surface active sites and finally chemical reaction. Understanding the nature of charge carries involved in these steps is therefore important for the recognition of photo-catalyst limitations. In particular in a number of materials strong electron-lattice interaction leads to carrier self-trapping. The influence of charge self-trapping on photo-catalytic activity however, is unclear. Basing on density functional theory calculation we show here that for the most popular photo-catalyst, TiO$_2$, the electron hole self-trapping leads to states of which the position in band gap is dependent on the local electrostatic environment and thereby the type of surface termination. This finding explains previously not understood trends of rutile and anatase surfaces in photo-deposition and photo-etching reactions. Furthermore it allows us to shed light on other important issues such as synergism of rutile and anatase mixtures and generally observed higher photocatalytic activity of the anatase phase. We anticipate that our results can aid the design of more reactive photo-catalysts based on TiO$_2$ and our approach can be utilized for other relevant photo-catalysts as well.
Titanium dioxide is abundant, harmless, and chemically inert therefore technologically a very attractive material. This businesslike motivation has driven an extensive research on TiO$_2$ and especially on its photo-catalytic properties. Many aspects of TiO$_2$ photocatalysis however, still remain obscure[1, 2]. Issues regarding different activities of rutile and anatase phases, surface termination dependence of oxidative properties and synergism in phase mixtures are especially important as these effects can directly be exploited in photocatalyst design. A clear illustration of such dependencies comes from observations of PbO$_2$ photo-deposition rates (see Fig.1). Bae et al.[3] found that for rutile nanorods terminated by {001}, {110}, {111} planes oxidation of Pb$^{2+}$ to PbO$_2$ takes place on {001} surfaces whereas reduction of PtCl$_6^{2-}$ to Pt takes place on {110} surfaces. In a similar experiment by Ohno et al. rutile {011} were more oxidative than {110} and anatase {001} were more oxidative than {011}[4]. Furthermore, in anodic photo-etching of rutile in aqueous sulfuric acid {001} and {100} planes were found the most and the least oxidative, respectively—TiO$_2$ dissolution (TiO$_2$ + h$^+$ + HSO$_4^-$ → O$_2$ + TiHSO$_4^{2+}$) occurs preferentially along the [001] direction and leads to formation of holes or grooves with {100} surfaces exposed[5, 6]. These experiments allow to order the surface facets by increasing oxidative properties: for rutile {100}<{110}<{011}<{001} and for anatase {011}<{001}.

A photocatalytic process relays on a sequence of a charge transport to surface reactive sites, and surface reaction steps. Depending on relative kinetics of these two steps the rate of the overall photocatalytic process can be limited by either of them. The photogenerated holes reach surface within picoseconds after the excitation [7, 8]. Many reactions, especially those involving nuclear rearrangements, occur on much longer time scales, for instance a microsecond hole transfer to toluene or acetonitril [9], or millisecond-second water oxidation and oxygen evolution [10]. Therefore, in those cases the population of photogenerated carries has sufficient time to attain a certain degree of thermal equilibrium, and their concentration on surfaces is determined by their stability on surface sites.

We show in the following that differences of excess surface hole density among rutile and anatase surfaces arise due to variation of spacial and energetic distribution of hole trapping states. Hole trapping states have been observed in many experiments including electron paramagnetic resonance (EPR), transient absorption spectroscopy (TAS) and photoluminescne (PL) (for a review see Fujishima et al.[1] and Henderson[2]) but their exact nature remained unclear. Only recently it is becoming more evident that holes in TiO$_2$ self-trap
forming O\textsuperscript{−} small polarons\cite{11–15}—an electronic hole localized on an oxygen lattice site surrounded by a deformed lattice. The hole trapping state is formed by a \( p \)-like orbital perpendicular to the flat OTi\(_3\) building blocks of TiO\(_2\). Our DFT calculation predicted that trapping in anatase is stronger than in rutile and the small-polaron stabilisation energy with respect to the delocalized holes in the valence band (VB) is 0.2 eV; in rutile the two types of hole states have comparable stability\cite{12}. DiValentin et al. found trapping strength of 0.75 eV in anatase\cite{13}. Here our focus is on the effect of surface termination on the trapping strength as this issue is particularly relevant to the understanding of the TiO\(_2\) photo-catalysis.

A surface, as any other crystal imperfection, induces lattice relaxation and charge redistribution. These processes create potential variations in surface layers. The localized nature of trapped hole states makes their energetics highly sensitive to such potential changes. Fig.2 shows a schematic energy diagram of a surface terminated semiconductor with upward bended bands. The hole trapping level \( \varepsilon_T \) (dashed line) is located in the band gap and in the same way as the VB and the CB edges it follows the space charge potential. At the very surface layers, however, crystal structure interruption give rise to potential variations that modify the stability of the trapped (localized) hole states.

In Fig.3 we plot the energy diagram for anatase \{001\} and \{011\} surfaces (for anatase \{100\} and rutile \{001\}, \{011\}, \{110\}, \{100\} see Supplementary Fig.6). The hole stabilisation energy (the trapping level) oscillates along the surface layers and converges to the bulk value within 1–2 nm. For most terminations the hole stabilisation energy is the largest at the surface oxygen bridge site. This site is doubly coordinated by Ti cations therefore a positive hole charge is less destabilized compared to OTi\(_3\) sites. An active role of bridging oxygen sites in photo-oxidation mechanisms is also supported by isotope labeling experiments\cite{6, 16}.

For surfaces composed of charged layers, such as anatase \{011\} formed by \( [O^2−(TiO)_2^{4+}O^2−]_n \), the energy strongly oscillates around the bulk value. For neutral layer stacking, as in case of anatase \{001\} composed of \([TiO_2]_n\), the trapping strength is more even and only the strengths of the surface-most trapping sites are significantly modified. Moreover, for some surfaces there are two possible hole orbital alignments with respect to the surface. For instance, for anatase \{011\} the lobe of the hole orbital can be parallel or nearly perpendicular to the surface (see Fig.4). In the former case the hole stability oscillates more strongly (blue circles in Fig.3(b)).
These observations suggest the electrostatic potential in the surface layers as responsible for the variation of the trapping strength. To check our presumption we construct a similar depth profile for the electrostatic energy \( U(z) = \int V(r)n_p(r - z)\,dr \) (see the bottom plots in Fig.3) where \( V(r) \) is the electrostatic potential, and \( n_p(r - z) \) is the charge density of the oxygen atomic \( p \) orbital centered at the oxygen lattice site at depth \( z \). Similarity between \( U(z) \) and \( \varepsilon_T(z) \) is clear. A stronger \( U(z) \) variation in case of hole states with orbital parallel to the surface arise because of the overlap of the hole density with the electrostatic potential that vary between surface layers. Electrostatic effects also explain the instability of the hole state on rutile \{100\}. This surface is formed by \([Ti^{4+}\,O_2^-]_n\) stacking (see Supplemental Fig.7 and Fig.6(a)) and the lobe of the hole orbital is immersed in the \( Ti^{4+} \) layer that destabilizes the positive hole charge. In contrast for the stable holes on \{001\} rutile and anatase surfaces the hole orbital is aligned parallel to neutral layers.

A quantity directly related to the surface electrostatic potential is the work function \( \phi = (\bar{V}^B - V^V) - \mu/e \) where the difference between the average electrostatic potential in the bulk \( \bar{V}^B \) and the reference value in the vacuum \( V^V \) is due to the surface dipole moment and \( \mu \) is the chemical potential of the electron—a bulk property[17]. In Fig.5 we plot the trapping strength of the hole states localized on the bridging oxygen sites \( \varepsilon^S_T \) against the work function. Intelligibly, the lower the work function the more stable the hole state is, as it is easier remove an electron. The correlation, however, is not linear as local effects are important. Nevertheless, now it is easy to see the trends in surface hole stability: for rutile \{100\}<\{110\}<\{011\}<\{001\}; for anatase \{011\}<\{100\}<\{001\}. These trends agree with experimental photo-deposition and photo-etching rates. Since surface trapping levels, with the exception of \{100\} rutile, are well above the VB edge the surface hole distribution will be dominated by the trapped rather than the VB holes. Therefore if photo-generated holes are in equilibrium between themselves the trend in hole stability will translate into the surface hole density. For instance hole stability of 1.1 eV on anatase \{001\} with respect to the bulk value will enhance the equilibrium surface hole density by \( p^S/p^B = \exp \left[ (\varepsilon^S_T - \varepsilon^B_T)/k_BT \right] \approx 10^{20} \) at room temperature. In a non-equilibrium situation such an enormous factor provides large driving force for hole transport to the surface and enhances electron-hole separation necessary for obtaining any photo-catalytic effect. An increase in \( O^- \) concentration with increasing \{001\} surface area has been observed in EPR experiment by D’Arienzo et al. and correlated with stronger photo-catalytic activity[14].
A higher hole stabilisation on most abundant anatase \{110\} and\{100\} compared to rutile \{110\} surfaces also reflects the fact that anatase is generally more photo-catalytically active. For most reactions self-trapped holes at surface should be sufficiently oxidative as the VB edge in TiO$_2$ lays quite high on the electrochemical scale (3.0 V [NHE])\cite{1}. For instance hole stabilization on anatase \{001\} of 1.3 eV reduces oxidative power to ca. 1.7 V [NHE] while for instance $E^0_{\text{PbO}_2/\text{Pb}^{2+}} = 1.46$ V [NHE]. For trapped hole states in anatase Lawless et al.\cite{18} and Tojo et al.\cite{19} reported oxidation potentials of ca. 1.5-1.7 V [NHE] from pulse raiolysis and flash photolyis experiments, respectively. Bahnemann et al. found two types of trapped states: a deeply trapped holes at ca. 1.5 V [NHE] not reacting with dichloroacetate and thiocyanate; and reactive shallowly trapped holes at higher redox potentials\cite{7}.

Further support for the surface hole self-trapping comes from observations of shifts of the flat band potential upon light irradiation. Hagfeldt et al.\cite{20} compared Mott-Schottky plots for TiO$_2$ nanocrystalline films under dark and UV-light conditions. Irradiated films showed larger capacitance and the response shifted anodicaly indicating presence of high density surface hole states. Since the self-trapping centers are associated with the oxygen lattice sites high density of trapping states is possible and can arise at strong UV illumination. Such high density of photo-generated surface hole states could also explain a dramatic improvement of Dye-Sensitized solar cell performance when exposed to UV light\cite{21, 22}. Electrostatic field induced by the positive surface hole charge will decrease the Schottky barrier at the metal/TiO$_2$ contact and therefore facilitate electron transfer.

Self-trapping is especially important for nano-sized TiO$_2$ particles. There the band bending do not develop fully and the facial dependence of trapping strength can be the only driving force for charge separation. Under a typical donor density $N_d = 10^{17}$ cm$^{-3}$ in TiO$_2$ for particle size of 20nm the potential drop across space charge layer is of the order of thermal energy\cite{23} thus irrelevant. Phase and morphology dependent hole self-trapping strengths will also enhance charge separation in mixtures. Such effect has been observed, in particular for Degussa P25\cite{24, 25}, and attributed to charge transfer between the two TiO$_2$ phases\cite{25, 26}. But, there is no consensus on the direction of such transfer. A simple consideration of the positions of the VB and the CB edges or the averaged work function\cite{27, 28} is not sufficient and the morphology dependent positions of surface hole (and electron) states has to be taken into account.

In conclusion, we have shown that the position of the hole trapping states in the band
gap vary among rutile and anatase facets. Differences in the hole trapping strengths provide a driving force for electron-hole separation and lead to the variation in facets activity toward oxidation processes. We think that this understanding could help to design more efficient photo-catalyst for instance by depositing an oxidation catalyst on an appropriate surface[29] or by tuning a nano-particle shape for a better charge separation step.
METHOD

We performed DFT calculations within the Projector-Augmented Wave formalism implemented in the GPAW code. Pseudo wave-functions, densities and potentials were represented on a uniform, real-space grid with a spacing of 0.2Å. To account for exchange-correlation effects we chose RPBE functional. Brillouin zone was sampled with a Monkhorst-Pack mesh ensuring that $ka \geq 18$ Å where $k$ is number of sampling points and $a$ is a periodicity in any direction.

We optimized lattice parameters of rutile ($P4_2/mmm$) and anatase ($I4_1/amd$) TiO$_2$ (rutile: $a=4.691$, $c=2.975$, $u=0.3061$; anatase: $a=3.829$, $c=9.744$, $u=0.2062$). Calculations were performed for supercells defined through tetragonal lattice vectors, $[a, b, c]$, of the respective crystallographic cells: For rutile $\{001\}$, $\{011\}$, $\{110\}$, $\{100\}$ surfaces we used $[a-b, a+b, 8c]$, $[-b+c, +a, 4b+4c]$, $[2c, a-b, 4(a+b)]$, $[b, 2c, 5a]$, respectively; For anatase $\{001\}$, $\{100\}$, $\{101\}$ we used: $[2a, 2b, 2c]$, $[2b, c, 4a]$, $[-a+c, -2b, 3a+3c]$, respectively.

To create an electron hole state we employed linear expansion $\Delta$-self consistent field ($\Delta$–SCF). The method allows to add/subtract the electron density of the specified orbital at each SCF cycle. The hole state was generated by removing the electron density of the oxygen $p$-like orbital perpendicular to $C_{2v}$ symmetric TiO$_3$ unit and placing it in the bottom of the CB. With such a constraint on the electronic structure we relaxed the atomic coordinates keeping one bottom layer of the slab fixed.

Convergence of the energy and the maximum force of 0.05 eV/Å was achieved in most cases. In some, however, the hole is unstable and the above convergence criterion has not been attained therefore there we report local minima. These does not change the overall picture as unstable states to not trap holes. Supplemental Fig. 9 shows that change in unit cell size have minor effect on the hole stabilisation depth profile.

Work function has been calculated as a difference between the vacuum potential and the Fermi level of a symmetric slab (both surfaces relaxed). Supplemental Fig. 10 shows convergence of the work function with respect to the slab thickness.

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FIG. 1: Schematic photo deposition experiment performed by Ohno et al.[4]. Different rutile facets have different photo-catalytic activity towards reduction and oxidation reactions— Pb$^{2+}$ oxidation and deposition of PbO$_2$ occurs on rutile {011}; reduction of PtCl$_6^{2-}$ and Pt deposition occurs on {110}. 
FIG. 2: Energy diagram for a \textit{n}-type semiconductor with upward band banding. Hole self-trapping energies $\varepsilon_T$ are sensitive to potential variation in surface layers of $\approx 1$ nm in thickens. $\varepsilon_{CB}$ and $\varepsilon_{VB}$ are the valence band and the conduction band edges, respectively; superscripts S and B denote surface and bulk values, respectively.
FIG. 3: Self trapping energies $\varepsilon_T$ with respect to the valence band edge for anatase {001} and {011} surfaces. In surface layers hole stabilisation energies oscillate and within 1-2 nm below the surface the profiles converge to the bulk value $\varepsilon_B^T$. Larger surface hole strapping strength on {001} facets explains their stronger oxidative reactivity compared. $U(z)$ is the overlap of the electrostatic potential $V(r)$ and the density of the hole orbital $n_p(r - z)$ centered at depth $z$. Similarity between $U(z)$ and $\varepsilon_T$ suggest that variation of trapping strength in surface layers is an electrostatic effect. The shaded area denotes the valence band.

FIG. 4: Two possible $p$-like orbital alignments along [011] direction in anatase.
FIG. 5: Correlation between the work functions $\phi$ and the stabilities of the self-trapped holes $\varepsilon_T$ for the different rutile and anatase surfaces. Shaded area denotes the Valence Band whereas dashed lines are the bulk self-trapping strengths $\varepsilon_B^T$. 

\[\Delta^\Sigma_{\varepsilon} \]
FIG. 6: Self trapping energies $\varepsilon_T$ with respect to the valence band edge for rutile and anatase surfaces. In surface layers hole stabilisation energies oscillate and within 1-2 nm below the surface the profiles converge to the bulk value $\varepsilon_B^T$. Larger surface hole trapping strengths in anatase reflects its generally stronger oxidative activity. The shaded area denotes the valence band.
FIG. 7: Rutile surfaces. Blue and red lines link the hole trapping sites for which the hole stabilization energies are plotted on Fig.6.
FIG. 8: Rutile surfaces. Blue and red lines link the hole trapping sites for which the hole stabilization energies are plotted on Fig.6.
FIG. 9: Hole stabilisation calculated with different cell sizes.

FIG. 10: Convergence of the work function with slab thickness.
Zawadzki P.; Transient absorption spectra of anatase TiO$_2$. (manuscript)
Transient absorption spectra of anatase TiO$_2$

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Abstract

We have performed density functional theory calculations of optical charge transfer transitions of small polaron O$^-$ centers in the anatase TiO$_2$ and assigned the experimentally observed trapped hole absorption range of 430-550 nm to stable surface and subsurface O$^-$ centers. Furthermore, since bulk centers absorb at 600-750 nm, subsurface centers at 430-600 nm, whereas surface centers at $>450$ nm, we link a blue shift of the spectra after excitation to holes transfer toward surface layers.
I. INTRODUCTION

Understanding charge carriers dynamics in a photoexcited semiconductor photocatalyst is critical for elucidation of factors limiting a photocatalyst performance. Semiconductor photocatalysis comprises several consecutive steps. The process begins with photogeneration of electron-hole pairs, then is followed by charge separation and transport to surface reactive sites, where finally chemical transformations occur. Studies of this dynamics require ultrafast techniques [1]. Transient absorption spectroscopy (TAS) is a technique that allows to monitor photogenerated carriers on a sub-picosecond time scale [1, 2]. The method employs a short femtosecond laser pules (pump) to photoexcite a semiconductor and then a second pules (probe) to measure time resolved absorption spectra.

TAS has been extensively used to study charge carrier dynamics in the most popular photocatalyst—anatase titanium dioxide. The TAS spectra of TiO$_2$ consist of free and trapped carriers contributions. The former can be explained with Drude-Lorentz model and follows $\lambda^n$ power law [3]. The latter is a broad feature located in the visible spectral range, but the optical transitions behind this contribution are unclear [4–9, 9, 10]. Particularly important is elucidation of optical transitions involving trapped holes as these carriers are predominately trapped [9] and TAS could help to elucidate the effects of charge trapping photocatalyst performance. Deriving such an insight from TAS spectra, however, requires at least knowledge of spacial and energetic distribution of hole trapping sites, and optical transitions energies associated with these centers.

The first two issues, only recently are becoming more clear. An electron hole in TiO$_2$ self-traps on the oxygen $p$-like orbital perpendicular to the OTi$_3$ building block of the anatase and rutile structures [11–13]—an O$^-$ small polarons is formed. Trapping strengths oscillate in surface layers and within 1-2 nm below surfaces converge to the bulk value [14].

Here, we analyze optical transition energies of O$^-$ centers. By means of the linear expansion $\Delta$ self-consistent field ($\Delta$-SCF) DFT [15] we calculate optical charge transfer transitions for hole trapping sites in anatase bulk and in surface layers of the (101) and the (001) facades. The obtained bands explain experimentally observed strong optical absorption of photogenerated holes in TiO$_2$ at 430-520 nm [4–9, 9, 10] and a blue shift of the spectra within picoseconds after excitation [4, 4–7, 16–18].
II. MODEL

FIG. 1: Location of trapping centers $X, Y_1, Y_2, Y_3, Z$. Arrows indicate the strongest transitions (oscillator strength $f > 10^{-3}$). Letters $A - E$ denote distinct charge transfer paths in the anatase bulk[19], and accompanied numbers denote nonequivalence of paths in surface layers.

FIG. 2: Self trapping energies $\varepsilon_T$ with respect to the valence band edge for anatase anatase $\{001\}$ and $\{101\}$ surfaces [14]. In surface layers hole stabilisation energies oscillate and within 1-2 nm below the surface the profiles converge to the bulk value $\varepsilon_B^T$. $U(z)$ is the electrostatic interaction energy of the electron density of the hole trapped at $z$ with the surface electrostatic potential. Similarity between $U(z)$ and $\varepsilon_T$ suggest that variation of trapping strength in surface layers is an electrostatic effect. The shaded area denotes the valence band.

A small polaron refers to a carrier localized on a single lattice site together with a surrounding lattice deformation. An optical charge transfer from one such center, $I$, to another, $F$, is often termed as an interpolaron transition [20]. On Fig.1 we illustrate this concept with
a single effective mode, two site model. Potential energy surfaces (PESs) for a small polaron state localized on sites $I$ and $F$ are $E_I(\rho) = \frac{1}{2} \hbar \Omega (\rho + s/2)^2 - \Delta_{IF}$, and $E_F(\rho) = \frac{1}{2} \hbar \Omega (\rho - s/2)^2$, respectively, where we use reduced coordinates $\rho = (m \Omega / \hbar)^{1/2} q$. $s$ is lattice distortion due to the electron-lattice interaction whereas $\Delta_{IF}$ describes relative bias toward charge localization on the site $I$. The interpolaron absorption band is due to optical transitions from the vibrational states located on $E_I$ to the vibrational states located on $E_F$. For large relative PES displacement, $s >> 1$, the $E_F$ can be treated classically and the band shape $G_{IF}$ is a Gaussian centered at $\hbar \omega_{IF}$ [21]:

$$G_{IF}(\omega) = \left[ \frac{w_{IF}}{\pi} \right]^{1/2} \exp \left[ (\hbar \omega - \hbar \omega_{IF})^2 w_{IF} \right]^{1/2}, \quad (1)$$

with $w_{IF}(T) = \tanh(\hbar \Omega / 2kT)/(s \hbar \Omega)^2$ and

$$\hbar \omega_{IF} = \hbar \Omega s^2 + \Delta_{IF}. \quad (2)$$

The absorption band of a single a small polaron center at $I$ is a sum over possible charge transfer paths $F$ weighted by their oscillator strength:

$$f_{IF}(E) = \frac{2 m_e \omega_{IF}}{3 \hbar} |\mu_{IF}|^2. \quad (3)$$

The electronic transition moment between states $|I\rangle$ and $|F\rangle$, $|\mu_{IF}| = |\langle I|(-e \mathbf{r})|F\rangle|$, can be approximated in a first order by [20]

$$|\mu_{IF}| \approx \frac{e t_{IF}}{\hbar} \frac{d_{IF}}{\hbar \omega_{IF}}, \quad (4)$$

FIG. 3: Schematic energy diagram for charge transfer transition. Initial and final states $|I\rangle$ and $|F\rangle$ are associated with a localized charge on site $I$ and $F$, respectively. $\Delta_{IF}$ is the relative shift of the initial and the final potential energy surfaces, $E_I$ and $E_F$; $\rho$ is lattice coordinate; $\hbar \Omega$ is the quantum of vibrational energy.
where $d_{IF}$ and $t_{IF}$ are the distance and the electronic coupling element, respectively, between sites $I$ and $F$.

III. METHOD

Interpolaron transitions can originate from bulk and surface trapping sites. In the anatase bulk, all oxygen lattice sites are equivalent therefore it is sufficient to consider transitions from one trapping site $I = X$ to its surrounding $F = A, B, ...$ (see Fig. 1). Anatase has several stable surface terminations and each surface layer contains up to two nonequivalent oxygen lattice sites. Therefore, due to large number of possible transitions, we limit our analysis to the most stable and often reported as photocatalytically the most active, the (101) and (001) anatase facades, respectively. For the (101) surface we consider three most stable hole trapping sites $Y_1, Y_2, Y_3$ located 0.48 eV, 0.52 eV, 0.36 eV above the valence band edge, respectively [14] (see Fig. 2(a) and Fig. 1). For the (001) surface we consider only transitions from the most stable trapping site $Z$, located 1.29 eV above the valence band edge [14] as subsurface centers are much less stable (see Fig. 2(b) and Fig. 1).

To calculate optical transition parameters we employ $\Delta$-SCF DFT [15]. This simple extension of the conventional DFT allows to calculate the total energy of a system with a constrained electron density. We form an $O^-$ center by removing the electron density of the oxygen $p$ orbital expanded in Kohn-Sham states from the total electron density, for details see Ref. [11, 19]. The system is kept neutral by adding an electron to the bottom of the conduction band.

The transition energy $\hbar \omega_{IF}$ is obtained as the energy difference between systems with an electron hole confined to $I$ site and to $F$ site at the equilibrium distortion associated with the site $I$ ($\rho_I$): $\hbar \omega_{IF} = E_F(\rho_I) - E_I(\rho_I)$.

The relative shift of PESs $\Delta_{IF}$ is the energy difference between states $|I\rangle$ and $|F\rangle$ calculated at their equilibrium distortions $\rho_I$ and $\rho_F$, respectively, and equals to trapping strength difference between sites $I$ and $F$:

$$\Delta_{IF} = E_I(\rho_I) - E_F(\rho_F) = \epsilon_T(I) - \epsilon_T(R). \quad (5)$$

where $\epsilon_T(I)$ and $\epsilon_T(F)$ are the trapping strengths (see Fig. 2 for trapping strengths profiles). To obtain the electron coupling $t_{IF}$ we construct a bonding and an antibonding combinations.
of hole orbitals $|+\rangle = (|I\rangle + |F\rangle)/\sqrt{2}$ and $|-\rangle = (|I\rangle - |F\rangle)/\sqrt{2}$, and calculate energy gap between systems with the hole density confined to these states at non-distorted structure: $t_{IF} = |E_+(0) - E_-(0)|/2$.

We have applied a similar procedure to calculate optical charge transfer transitions of the $V^-$ center in MgO. After correction for the delocalization error the results were in good agreement with the experimental data [22]. Here the situations is simpler as the initial and final states have the same degree of localization—they are localized on a single site—thus no delocalization error correction is needed.

We perform RPBE DFT[23] calculations within the Projector Augmented Wave formalism implemented in the GPAW code[24]. The wave-functions/densities and potentials are described on a grid with a spacing of 0.2 Å. Atomic structures are defined by lattice vectors: $\vec{a}' = 3\vec{a}$, $\vec{b}' = 3\vec{b}$, $\vec{c}' = 2\vec{c}$ for the bulk and for the (001) surface, and $\vec{a}' = (-\vec{a} + \vec{c})$, $\vec{b}' = -3\vec{b}$, $\vec{c}' = 3(\vec{a} + \vec{c})$ for the (101) surface; $\vec{a}$, $\vec{b}$, $\vec{c}$ being the vectors of the respective tetragonal crystallographic cells. The lattice constants are optimized: $|\vec{a}| = |\vec{b}| = 3.829$, $|\vec{c}| = 9.744$ [11]. For surface slabs no periodic boundary condition in the direction normal to the surface, and a vacuum layer of 5Å were applied. During geometry optimization two bottom layers of the slabs were kept fixed. All cells contain 216 atom and the Brillouin zone is sampled on a 2x2x1 Monkhorst-Pack mesh.

IV. RESULTS

In Tab. I we present characteristics parameters of the strongest ($f > 10^{-3}$) interpolaron transitions. Transfers of type $A$ and $B$ dominate the absorption of the bulk ($X$) and the (101) surface centers ($Y_1$, $Y_2$, $Y_3$). $A$ and $B$ are not possible for the $Z$ trapping center due to specificity of the anatase (001) surface termination. Transitions energies are most easily analyzed with Eq. 2. For the (101) surface hole stability oscillates in surface layers and converges to the bulk value at larger depths (see Fig. 2(a)). Therefore $\Delta_{IF}$ will gradually decay to zero as we move from the surface to the bulk trapping centers. Transitions from deeper surface layers of the (101) surface will therefore be positioned between the $Y_3$ surface and the $X$ bulk transitions. Subsurface trapping sites in the (001) surface layers are much less stable than the surface center $Z$, therefore no significant occupation is expected at any time after the photo excitation. Furthermore, the trapping strength for this facade only
TABLE I: Parameters for the strongest (oscillator strength $f > 10^{-3}$) charge transfer optical transitions from sites $I \in X, Y_1, Y_2, Z$ to neighboring sites $F$. $n_F$ denotes number of equivalent sites $F$; $d_{IF}$ is the distance between $I$ and $F$; $h\omega_{IF}$ is the transitions energy; $\Delta_{IF}$ is the relative displacement of the potential energy surfaces $E_I$ and $E_F$; $t_{IF}$ is the electronic coupling and $f_{IF}$ is the oscillator.

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weakly oscillates in surface layers (see Fig. 2(b)) therefore transition energies from subsurface sites will be close to those originating from the bulk.

In Fig. 4 we show absorption bands for X, Y1, Y2, Y3, and Z centers calculated at $T = 300$ K and $h\Omega = 40$ meV [19]. Bulk centers absorb at 600-750 nm, subsurface sites at 430-600 nm, whereas surface centers at >450 nm.

V. DISCUSSION

Charge transfer transitions energies (Eq. 2) are strongly dependent on a relative difference of charge trapping strengths between the initial and final states ($\Delta_{IF}$). The hole trapping strength profiles oscillate in surface layers, and are dependent on the type of surface termination. This explains experimentally observed sensitivity of TAS spectra to TiO$_2$ morphology [16].

The time evolution of TAS spectra of photoexcited TiO$_2$ is characterised by several time scales. After excitation holes trap within 50-200 fs [4, 16, 25, 26]. The absorption spectra then blue shifts within 1-3 ps to 550 nm [4, 5, 16, 18] and then to 450 nm within the next 20-100 ps [4–7, 17]. The shape then remains unchanged on a nanosecond time scale [4–8, 17, 27]. Basing on the calculated optical transition energies, these spectral changes can be attributed to hole transfer toward surfaces. On a femtosecond time scale the transfer is likely due to hot holes as the trapping time increases for higher energy pump photons. The change of the spectra within 1-3 ps may be linked to hole transport after the trapping and the 550 nm spectra range corresponds to subsurface trapping sites (below Y2 or Z). This fast change, however, can not be explained with the hopping mechanism as a single hop would take a similar time. For a barrier height $E_b = 0.1$ eV and an effective mode quantum $h\Omega = 40$ meV [19] a single hop at $T = 300$ K occurs on average every $\tau \approx (2\pi/\Omega) \exp(E_b/kT) = 8$ ps. Since the hopping mechanism also underestimates high temperature hole hopping mobility [19], we suggest that thermally excited to the valence band holes contribute to hole transport mechanism. Spectral changes on 20-100 ps time scale are likely due to hopping transport of deeply trapped holes in surface layers.

By scavenging one of the carriers, the absorption of trapped holes has been attributed to 430-550 nm range of TAS spectra [4–7, 17]. This part of the spectra corresponds to the interpolaronic transitions from the surface and the immediate subsurface centers—the most
FIG. 4: Optical absorption spectra of the self-trapped hole in anatase TiO$_2$. Absorption bands from the $X, Y_1, Y_2, Y_3, Z$ trapping centers (see Fig. 1) are marked by colored peaks. Experimental hole absorption spectra are marked with lines—full: 20 nm TiO$_2$ (hole scavenged by CD$_3$OD) time resolution 50 ns [9]; dashed: 2.4 nm TiO$_2$ (electron scavenged by Pt(1%)) measured after 5 $\mu$s [30]; dash-dotted: 2.4 nm TiO$_2$ (electron scavenged by Pt(1%)) measured after 20 ns [30]; dotted: 15 nm TiO$_2$ (electrons scavenged by Pt(1.4%)), measured after 20 $\mu$s [10].

stable hole trapping sites. Furthermore, the tail of the hole absorption band extends to long wavelengths (see Fig. 4) therefore subsurface trapping is evident and may limit hole availability for photooxidation reactions. Since the stability of surface and subsurface sites is comparable for the (101) facade, in contrast to the (001) facade where the surface trapping is much stronger, the subsurface trapping can partially account for the observed weaker photooxidative activity of the (101) compared to the (001) facade [28, 29].

VI. CONCLUSION

In conclusion, we have calculated optical charge transfer transitions of the O\textsuperscript{−} centers in anatase TiO$_2$. Bulk centers absorb at 600-750 nm, subsurface centers at 430-600 nm, whereas surface centers at >450nm. A picosecond blue shift of the transient absorption spectra can be associated with the photogenerated hole transfer to surfaces.

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